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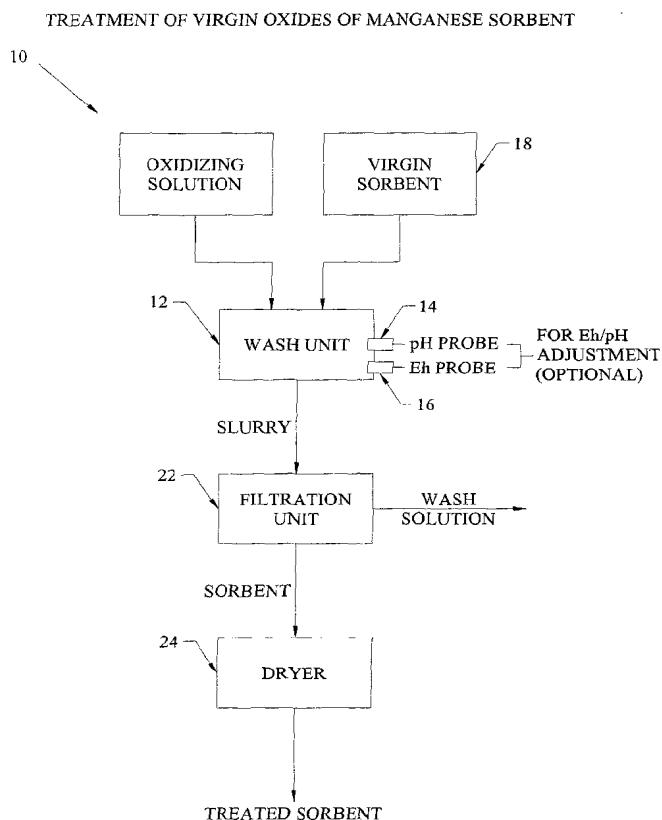
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(54) Title: PRETREATMENT AND REGENERATION OF OXIDES OF MANGANESE



(57) Abstract: The invention relates to systems and processes for treating particulate oxides of manganese useful as oxidizing sorbents for capturing or removing target pollutants from industrial gas streams, including, but not limited to, nitrogen oxides (NO_x), sulfur oxide (SO_x), mercury (Hg), hydrogen sulfide (H₂S), other totally reduced sulfides (TRS), and oxides of carbon (CO and CO₂) gases. Oxides of manganese are washed an aqueous oxidizing solution, which may be adjusted as necessary to maintain the oxidizing solution a desired range of pH (acidity) and Eh (oxidizing potential) within the MnO₂ stability area for aqueous solutions. The resulting treated oxides of manganese are equally or more efficient as sorbents as the oxides of manganese processed with the invention.

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PRETREATMENT AND REGENERATION OF OXIDES OF MANGANESE

5 Related Applications

This application claims priority to US Provisional Application No. 60/342,587 filed December 21, 2001, which is incorporated herein by reference.

10 Field of the Invention

The invention relates to systems and processes for treating oxides of manganese that may be utilized as a sorbent for capture and removal of target pollutants from industrial and other gas streams. Further, the invention relates to pollution removal systems incorporating
15 such methods and apparatus and to oxides of manganese, oxides of manganese sorbent particles, and oxides of manganese filter cake formed by the processes of the invention.

Background of the Invention

The element manganese (Mn) may exist in six different valence (oxidation) states. Of
20 particular interest and usefulness in the Pahlman™ systems and processes are those oxides of manganese having valence states of +2, +3, and +4, which correspond to the oxides MnO, Mn₂O₃, and MnO₂. The oxide MnO₄ is probably a solid-solution of both the +2 and +3 states.

A characteristic of most oxides of manganese species is non-stoichiometry; that is,
25 most oxides of manganese molecules or MnO₂ species typically contain on average less than the theoretical number of 2 oxygen atoms, with numbers more typically ranging between 1.5 to 2.0. The non-stoichiometry characteristic is thought to result from solid-solution mixtures of two or more oxide species, and exists in all but the beta (β), or pyrolusite, form of manganese dioxide. Oxides of manganese having the formula MnOX where X is about 1.5 to
30 about 2.0 are particularly suitable for dry removal of target pollutants from gas streams. However, the most active types of oxides of manganese for use as a sorbent for target pollutant removal usually have the formula MnO_{1.7 to 1.95}, which translates into manganese valence states of +3.4 to +3.9, as opposed to the theoretical +4.0 state. It is unusual for average valence states above about 3.9 to exist in most forms of oxides of manganese. The

formula MnO_2 , as used herein, symbolically represents all varieties of manganese dioxide including those with valence states ranging from +3 to +4, or $\text{MnO}_{1.5-2.0}$.

Oxides of manganese are known to exhibit several identifiable crystal structures, which result from different assembly combinations of their basic molecular structural units.

5 These basic structural “building block” units are MnO_6 octahedra, which consist of one manganese atom at the geometric center, and one oxygen atom at each of the six apex positions of an octahedral geometrical shape. The octahedra may be joined together along their edges and/or corners, to form “chain” patterns, with void spaces (“tunnels”). Regular (and sometimes irregular) three-dimensional patterns consist of layers of such “chains” and
10 “tunnels” of joined octahedra. These crystalline geometries are identified by characteristic x-ray diffraction (XRD) patterns. Most oxides of manganese are classifiable into one or more of the six fundamental crystal structures, which are called alpha (α), beta (β), gamma (γ), delta (δ), epsilon (ϵ), and ramsdellite. Certain older literature also included rho (ρ) and lambda (λ) structures, which are now thought obsolete, due partly to improvements in XRD
15 technique. Some (amorphous) forms of MnO_2 exhibit no crystalline structure.

Certain characteristics of oxides of manganese probably arise from the size and shape of voids within these crystalline patterns and from certain elements, and compounds, which may occupy the voids and appear to help prevent collapse of certain structures. Applicants believe that these characteristics in addition to the oxidation state may have and affect upon
20 the loading capacity of oxides of manganese sorbent. Further, many oxides of manganese are hydrous, and include structurally bound water. This bound water may also contribute to chemical reactivity and possibly catalytic behavior of the species.

Some oxides of manganese have the ability to absorb oxygen from gas. Manganous oxide (MnO) will oxidize to MnO_2 in the presence of air, for example. Additionally, the
25 dioxides are themselves oxidizers, they readily exchange oxygen in chemical reactions, and they are known to have catalytic properties. This oxygen exchange ability may be related to proton mobility and lattice defects common within most MnO_2 crystal structures. The oxidizing potential of MnO_2 is advantageously utilized in target pollutant removal in the Pahlman™ and other systems and processes. Target pollutants, such as NO_x and SO_2 gases,
30 mercury (Hg) and other pollutants, require oxidation of the species prior to reaction with MnO_2 sorbent to form reaction products, such as manganese sulfates and nitrates, mercury compounds, and other corresponding reaction products, in order for them to be captured and removed from gas stream.

Manganese compounds are soluble in water in the +2 valence state, but not in the +4 state. Therefore Mn^{+2} compounds, including MnO are readily soluble in aqueous solutions, as opposed to MnO_2 . During the formation of reaction products such as manganese nitrates and sulfates, the manganese is reduced from about the +4 state to the +2 state. This property
5 allows the reaction products formed on the surface of oxides of manganese sorbent particles to be readily dissolved and removed from the sorbent particles in aqueous solutions by disassociation into sulfate, nitrate, and Mn^{+2} ions.

Manganese dioxides are divided into three origin-based categories, which are: 1) natural (mineral) manganese dioxide (NMD), 2) chemical manganese dioxide (CMD), and 3)
10 electrolytic manganese dioxide (EMD). As implied, NMD occurs naturally as various minerals, which may be purified by mechanical or chemical means. The most common form of NMD is pyrolusite (β - MnO_2), which is inexpensive, but has rather low chemical activity and therefore low pollutant loading capacity. CMD and EMD varieties are synthetic. EMD is produced primarily for the battery industry, which requires relatively high bulk density
15 (which often results from relatively large, compact particles), relatively high purity, and good electrochemical activity. Though useful as a sorbent, characteristics such as low surface area and large compact particle size make EMD somewhat inferior to CMD for gas removal applications, despite its good electrochemical activity. Chemically synthesized oxides of manganese of all kinds falls into the CMD category and includes chemically treated oxides of
20 manganese. In chemical synthesis, a great deal of control is possible over characteristics such as particle size and shape, porosity, composition, surface area, and bulk density in addition to electrochemical or oxidation potential. It is believed that these characteristic contribute the loading capacity of some oxides of manganese.

EnviroScrub Technologies Corporation has developed pollutant removal systems and
25 processes utilizing dry and wet removal techniques and combinations thereof, incorporating the use of oxides of manganese as a sorbent. These systems and processes, commonly known as Pahlman™ systems and processes are the subject of co-pending U.S. Patent Application Numbers 09/919,600, 09/951,697, 10/044,089 and 10/025,270, the disclosures of which are incorporated herein. High target pollutant removal efficiencies have been obtained utilizing
30 the Pahlman™ systems and processes with oxides of manganese as the sorbent. Due to pollutant loading during the removal process, the Pahlman™ system or some of its system components must be periodically taken off-line so that sorbent may be removed for regeneration and recovery of useful by-products. The frequency of such disruptions and

related downtime could be decreased if it were possible to increase the loading capacity of the sorbent. It would therefore be desirable to enhance the loading capacities of the oxides of manganese in order to extend the period of sorbent use and its loading capacity. Applicants have developed methods of treating virgin oxides of manganese and of recycle processing of loaded oxides of manganese with oxidants or oxidizers that result in treated oxides of manganese having enhanced or increased loading capacity.

Brief Description of the Drawings

Figure 1 is a block flow diagram depicting an embodiment of a treatment system and method of the invention.

Figure 2 is a block flow diagram depicting an embodiment of a treatment system and method of the invention.

Figure 3 is a sorbent loading graph.

Figure 4 is a sorbent loading graph.

Figure 5 is a sorbent loading graph.

Figure 6 is a sorbent loading graph.

Figure 7 is a block flow diagram of a treatment system and method of the invention incorporating a controller.

Figure 8 is a block flow diagram of a embodiment of a treatment system and method of the invention incorporating a controller.

Figure 9 is a Pourbaix diagram for an aqueous solution of 1 mole/liter manganese ion concentration.

Figure 10 is a Pourbaix diagram for an aqueous solution of 10^{-6} mole/liter manganese ion concentration.

Summary of the Invention

The invention relates to systems and processes for treatment of oxides of manganese that may be utilized as a sorbent for removal of target pollutants from a gas stream.

An embodiment of a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream comprises the steps of washing virgin oxides of manganese in wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area; and filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of

manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.

Another embodiment of a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream comprises the steps of washing virgin oxides of manganese in a wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area; monitoring and adjusting the pH and/or the Eh values of the solution so as to maintain the Eh and pH values of the solution within the MnO_2 stability area; and filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese. The monitoring and adjusting step may be carried out by a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control of within the wash unit of the temperature, Eh values, and pH values in order to maintain conditions of the aqueous oxidizing solution within the MnO_2 stability area.

An embodiment of a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream comprises the steps of washing virgin oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution to form a filtrate and a pretreated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area; and removing the pretreated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.

An embodiment of a process for regeneration of loaded oxides of manganese formed through reaction between unreacted oxides of a manganese and target pollutants in a gas stream comprises the steps of washing loaded oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution having Eh and pH values within the MnO_2 stability area to form a filtrate and a regenerated oxides of manganese filter cake; and removing the regenerated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese from which the loaded oxides of manganese are formed.

An embodiment of a process for regeneration of loaded oxides of manganese sorbent particles bearing a reaction product layer of the surface thereof formed during reaction between unreacted oxides of manganese sorbent particles and target pollutants in a gas stream in a pollution removal system comprises the steps of rapidly washing and filtering the loaded
5 oxides of manganese sorbent particles in a rapid filtration wash unit with an aqueous oxidizing solution to dissolve the reaction product layer from the surface of the loaded oxides of manganese sorbent particles into the solution to form a filtrate and a regenerated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area; and removing the regenerated oxides of manganese filter cake from the rapid
10 filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese sorbent particles from which the loaded oxides of manganese sorbent particles are formed.

The above processes may further comprise the steps of drying the filter cake; and comminuting and sizing the dried filter cake to provide oxides of manganese particles. The
15 may alternative further comprise the steps of drying the filter cake; and comminuting and sizing the dried filter cake to provide oxides of manganese particles for introduction into a feeder or reaction chamber of a dry pollution removal system. In a further alternative, they processes may further comprise the steps of drying the filter cake; comminuting and sizing the dried filter cake to provide oxides of manganese particles for introduction into a feeder or
20 reaction chamber of a dry pollution removal system; and introducing the comminuted and sized oxides of manganese particles into the feeder or reaction chamber. In yet a further alternative, the above described processes may further comprise the step of conveying the filter cake to a dryer configured to inject the a wet filter cake or a slurry of oxides of manganese sorbent into the flow of a gas stream prior to introduction into a reaction chamber
25 of a pollutant removal system. In yet another further alternative, the above-described processes may further comprise the steps of conveying the filter cake to a dryer configured to inject the a wet filter cake or a slurry of oxides of manganese sorbent into the flow of a gas stream prior to introduction into a reaction chamber of a pollutant removal system; and injecting the wet filter cake or the slurry into the reaction chamber.

30 In the above-described processes the aqueous oxidizing solution contains an oxidizer. The oxidizer may be selected from the group consisting of hypochlorites, perchlorates, permanganates, oxygen (O_2), air, ozone, peroxides, persulfates, and combinations thereof.

13 An embodiment of a system for pretreatment of virgin oxides of manganese comprising a wash unit configured to hold and agitate a slurry of virgin oxides of manganese in an aqueous oxidizing solution, the solution have Eh and pH values within the MnO₂ stability area, the wash unit being optionally equipped with a pH probe, an Eh probe, and a
5 temperature probe, the wash unit being further configured to receive the slurry of virgin oxides of manganese or to individually receive virgin oxides of manganese and the aqueous oxidizing solution; a filtration unit configured to receive the slurry from the wash unit and to filter the slurry to form a filtrate and a pretreated oxides of manganese filter cake; an aqueous oxidizing solution vessel containing a supply of aqueous oxidizing solution, the solution
10 having Eh and pH values within the MnO₂ stability area, the vessel having a feeder configured to feed aqueous oxidizing solution to the wash unit and being optionally equipped with an Eh probe; an oxides of manganese vessel containing a supply of virgin oxides of manganese, the vessel having a feeder configured to feed oxides of manganese directly to the wash unit or, in conjunction with the aqueous oxidizing solution feeder to feed a slurry of
15 virgin oxides of manganese to the wash unit; and a pH adjust vessel having a supply of acid or base or separate supplies of acid and base, the pH adjust vessel having a feeder configured to feed acid and/or base to the wash unit. The system of this embodiment may further comprise a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control within the wash
20 unit of the temperature, Eh values, and pH values in order to maintain conditions of the aqueous oxidizing solution within the MnO₂ stability area.

This embodiment of a system for treatment of virgin or loaded oxides of manganese may further comprise a dryer for drying the filter cake; a device for comminuting and sizing the dried filter cake to form oxides of manganese particles; and a reaction chamber of a
25 pollutant removal system into which the oxides of manganese particles are introduced to capture target pollutants from a gas, the reaction chamber being equipped with at least one target pollutant concentration reader for measuring target pollutant concentration of the gas as it exits the reaction chamber, the reader being in electronic communication with the controller for checking the loading performance of the oxides of manganese particles and signaling
30 need for adjustment of operational parameters within the wash unit.

14 Another embodiment of a system for treatment of virgin or loaded oxides of manganese comprising a rapid filtration wash unit, the wash unit being configured to individually receive oxides of manganese and an aqueous oxidizing solution having a Eh and

pH values within the MnO_2 stability area, the wash unit being further configured to rapidly remove the aqueous oxidizing solution from contact with the oxides of manganese forming a filtrate and a treated oxides of manganese filter cake; an aqueous oxidizing solution vessel containing a supply of aqueous oxidizing solution, the solution having Eh and pH values
5 within the MnO_2 stability area, the vessel having a feeder configured to feed aqueous oxidizing solution to the wash unit and being optionally equipped with a probe selected from the group consisting of an Eh probe, a pH probe, a temperature probe, or any combination thereof; an oxides of manganese vessel containing a supply of virgin or loaded oxides of manganese, the vessel having a feeder configured to feed oxides of manganese to the wash
10 unit; optionally, a oxidizer vessel containing a supply of oxidizer, the oxidizer vessel having a feeder configured to feed oxidizer to the aqueous oxidizing solution vessel; and optionally, a pH adjust vessel having a supply of acid or base or separate supplies of acid and base, the pH adjust vessel having a feeder configured to feed acid and/or base to the aqueous oxidizing solution vessel. The system of this embodiment may further comprise a controller capable of
15 individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control of the temperature, Eh values, and pH values within the aqueous oxidizing solution vessel in order to maintain conditions of the aqueous oxidizing solution within the MnO_2 stability area.

This embodiment of a system for treatment of virgin or loaded oxides of manganese
20 may further comprise a dryer for drying the filter cake; a device for comminuting and sizing the dried filter cake to form oxides of manganese particles; and a reaction chamber of a pollutant removal system into which the oxides of manganese particles are introduced to capture target pollutants from a gas, the reaction chamber being equipped with at least one target pollutant concentration reader for measuring target pollutant concentration of the gas as
25 it exits the reaction chamber, the reader being in electronic communication with the controller for checking the loading performance of the oxides of manganese particles and signaling need for adjustment of operational parameters within the aqueous oxidizing solution vessel.

Another embodiment of a system for pretreatment of virgin oxides of manganese comprises a wash unit configured to hold and agitate a slurry of virgin oxides of manganese
30 in an aqueous oxidizing solution, the solution have Eh and pH values within the MnO_2 stability area, the wash unit being equipped with a pH probe, an Eh probe, and a temperature probe, the wash unit being further configured to receive the slurry of virgin oxides of manganese or to individually receive virgin oxides of manganese and the aqueous oxidizing

solution; a filtration unit configured to receive the slurry from the wash unit and to filter the slurry to form a filtrate and a pretreated oxides of manganese filter cake; an aqueous oxidizing solution vessel containing a supply of aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area, the vessel having a feeder
5 configured to feed aqueous oxidizing solution to the wash unit and being equipped with an Eh probe; an oxides of manganese vessel containing a supply of virgin oxides of manganese, the vessel having a feeder configured to feed oxides of manganese directly to the wash unit or, in conjunction with the aqueous oxidizing solution feeder to feed a slurry of virgin oxides of manganese to the wash unit; a pH adjust vessel having a supply of acid or base or separate
10 supplies of acid and base, the pH adjust vessel having a feeder configured to feed acid and/or base to the wash unit; and a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control within the wash unit of the temperature, Eh values, and pH values in order to maintain conditions of the aqueous oxidizing solution within the MnO_2 stability area, the controller
15 being electronic communication with the probes and feeders of the system.

This embodiment of a for pretreatment of virgin oxides of manganese may further comprise a dryer for drying the filter cake; a device for comminuting and sizing the dried filter cake to form oxides of manganese particles; and a reaction chamber of a pollutant removal system into which the oxides of manganese particles are introduced to capture target
20 pollutants from a gas, the reaction chamber being equipped with at least one target pollutant concentration reader for measuring target pollutant concentration of the gas as it exits the reaction chamber, the reader being in electronic communication with the controller for checking the loading performance of the oxides of manganese particles and signaling need for adjustment of operational parameters within the wash unit.

18 Another embodiment of a system for treatment of virgin or loaded oxides of manganese comprises a rapid filtration wash unit, the wash unit being configured to individually receive oxides of manganese and an aqueous oxidizing solution having a Eh and pH values within the MnO_2 stability area, the wash unit being further configured to rapidly remove the aqueous oxidizing solution from contact with the oxides of manganese forming a
30 filtrate and a treated oxides of manganese filter cake; an aqueous oxidizing solution vessel containing a supply of aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area, the vessel having a feeder configured to feed aqueous oxidizing solution to the wash unit and being equipped with a probe selected from the group

consisting of an Eh probe, a pH probe, a temperature probe, or any combination thereof; an oxides of manganese vessel containing a supply of virgin or loaded oxides of manganese, the vessel having a feeder configured to feed oxides of manganese to the wash unit; a oxidizer vessel containing a supply of oxidizer, the oxidizer vessel having feeder configured to feed
5 oxidizer to the aqueous oxidizing solution vessel; a pH adjust vessel having a supply of acid or base or separate supplies of acid and base, the pH adjust vessel having a feeder configured to feed acid and/or base to the aqueous oxidizing solution vessel; and a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control of the temperature, Eh values, and pH
10 values within the aqueous oxidizing solution vessel in order to maintain conditions of the aqueous oxidizing solution within the MnO_2 stability area, the controller being in electronic communication with the probes and feeders of the system.

This embodiment of a system for treatment of virgin or loaded oxides of manganese may further comprise a dryer for drying the filter cake; a device for comminuting and sizing
15 the dried filter cake to form oxides of manganese particles; and a reaction chamber of a pollutant removal system into which the oxides of manganese particles are introduced to capture target pollutants from a gas, the reaction chamber being equipped with at least one target pollutant concentration reader for measuring target pollutant concentration of the gas as it exits the reaction chamber, the reader being in electronic communication with the controller
20 for checking the loading performance of the oxides of manganese particles and signaling need for adjustment of operational parameters within the aqueous oxidizing solution vessel.

In the above-described systems the aqueous oxidizing solution contains an oxidizer. The oxidizer may be selected from the group consisting of hypochlorites, perchlorates, permanganates, oxygen (O_2), air, ozone, peroxides, persulfates, and combinations thereof.

25 The invention also relates to oxides of manganese, oxides of manganese particles, and oxides of manganese filter cakes formed by the above-described processes.

Oxides of manganese particles may be formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream comprising the steps of washing virgin oxides of manganese in wash unit with an aqueous
30 oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area; filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese; drying

the filter cake; and comminuting and sizing the dried filter cake to form oxides of manganese particles.

Oxides of manganese particles may be formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of washing virgin oxides of manganese in a wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area; monitoring and adjusting the pH and/or the Eh values of the solution so as to maintain the Eh and pH values of the solution within the MnO_2 stability area; filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese; drying the filter cake; and comminuting and sizing the dried filter cake to form oxides of manganese particles.

Oxides of manganese particles may be formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream comprising the steps of washing virgin oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution to form a filtrate and a pretreated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area; removing the pretreated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese; drying the filter cake; and comminuting and sizing the dried filter cake to form oxides of manganese particles.

Oxides of manganese particles may be formed by a process for regeneration of loaded oxides of manganese formed through reaction between unreacted oxides of a manganese and target pollutants in a gas stream comprising the steps of washing loaded oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution having Eh and pH values within the MnO_2 stability area to form a filtrate and a regenerated oxides of manganese filter cake; removing the regenerated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese from which the loaded oxides of manganese are formed; drying the filter cake; and comminuting and sizing the dried filter cake to form oxides of manganese particles.

Oxides of manganese sorbent particles may be formed by a process for regeneration of loaded oxides of manganese sorbent particles bearing a reaction product layer of the surface

thereof formed during reaction between unreacted oxides of manganese sorbent particles and target pollutants in a gas stream in a pollution removal system, comprising the steps of rapidly washing and filtering the loaded oxides of manganese sorbent particles in a rapid filtration wash unit with an aqueous oxidizing solution to dissolve the reaction product layer from the surface of the loaded oxides of manganese sorbent particles into the solution to form a filtrate and a regenerated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area; removing the regenerated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese sorbent particles from which the loaded oxides of manganese sorbent particles are formed; drying the filter cake; and comminuting and sizing the dried filter cake to form oxides of manganese particles.

Oxides of manganese filter cakes particles may be formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of washing virgin oxides of manganese in a wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area; monitoring and adjusting the pH and/or the Eh values of the solution so as to maintain the Eh and pH values of the solution within the MnO_2 stability area; and filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.

Oxides of manganese filter cake may be formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the step of washing virgin oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution to form a filtrate and a pretreated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area; wherein the oxides of manganese of the pretreated oxides of manganese filter cake have a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.

Oxides of manganese filter cake formed by a process for regeneration of loaded oxides of manganese formed through reaction between unreacted oxides of a manganese and target pollutants in a gas stream comprising the step of washing loaded oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution having Eh and pH values

within the MnO_2 stability area to form a filtrate and a regenerated oxides of manganese filter cake; wherein the oxides of manganese of the regenerated oxides of manganese filter cake have a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese from which the loaded oxides of manganese are formed.

5 Oxides of manganese filter cake may be formed by a process for regeneration of loaded oxides of manganese sorbent particles bearing a reaction product layer of the surface thereof formed during reaction between unreacted oxides of manganese sorbent particles and target pollutants in a gas stream in a pollution removal system comprising the step of rapidly washing and filtering the loaded oxides of manganese sorbent particles in a rapid filtration
10 wash unit with an aqueous oxidizing solution to dissolve the reaction product layer from the surface of the loaded oxides of manganese sorbent particles into the solution to form a filtrate and a regenerated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area; wherein the oxides of manganese in the regenerated oxides of manganese filter cake have a pollutant loading capacity equal to or greater than the pollutant
15 loading capacity of the unreacted oxides of manganese sorbent particles from which the loaded oxides of manganese sorbent particles are formed.

In the processes for formation of the above-described oxides of manganese particles and oxides of manganese filter cakes, the aqueous oxidizing solution contains an oxidizer. The oxidizer may be selected from the group consisting of hypochlorites, perchlorates,
20 permanganates, oxygen (O_2), air, ozone, peroxides, persulfates, and combinations thereof.

Detailed Description of Preferred Embodiments

The following definitions will be useful in understanding the invention disclosed herein:

25 “Reacted” or “loaded,” as used interchangeably herein, refers in conjunction with “oxides of manganese” and/or “sorbent” to oxides of manganese or sorbent that has interacted with one or more target pollutants in a gas whether by chemical reaction, adsorption or absorption. The term does not mean that all reactive or active sites of the sorbent have been utilized as all such sites may not actually be utilized.

30 “Unreacted” or “virgin,” as used interchangeably herein, refers in conjunction with “oxides of manganese” and/or “sorbent” to oxides of manganese or sorbent that has not interacted with target pollutants in a gas or gas stream.

“Nitrates of manganese,” as used herein, refers to and includes the various forms of manganese nitrate, regardless of chemical formula, that may be formed through the chemical reaction between NO_x and the sorbent and includes hydrated forms as well.

“Sulfates of manganese,” as used herein, refers to and includes the various forms of manganese sulfate, regardless of chemical formula that may be formed through the chemical reaction between SO_x and the sorbent and includes hydrated forms as well.

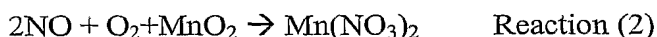
“Target pollutant,” as used herein, refers to the pollutant or pollutants that are or are to be captured and removed from a gas stream.

“ MnO_2 stability area,” as used herein, refers to the region of thermodynamic stability for manganese dioxide delineated by Eh and pH values for aqueous solutions. More specifically, it refers to the region of thermodynamic stability for manganese dioxide delineated by Eh and pH values for aqueous solutions in an electrochemical stability diagram, such as presented by Pourbaix diagrams.

Oxides of manganese may be utilized for various applications. one such application is in the use as a sorbent for removal of target pollutants in gas streams. Examples of target pollutants that may be removed with an oxide of manganese sorbent, include but are not limited to, NO_x , SO_x , mercury (Hg) and some mercury compounds, H_2S and other totally reduced sulfides (TRS), and oxides of carbon. As previously noted above, certain target pollutant removal systems and processes methods utilizing oxide of manganese sorbents and referred to as PahlmanTM systems and PahlmanTM processes are described and disclosed in co-pending U.S. patent application numbers 09/919,600, 09/951,697, 10/044,089 and 10/025,270, all assigned to EnviroScrub Technologies Corporation, the assignee of this application. The disclosures of these four patent applications are incorporated herein by reference.

Oxides of manganese sorbents are introduced into these and other pollution removal systems and interact with the target pollutants in gas streams routed through the systems as a catalyst, a reactant, an absorbent or an adsorbent.

During such interaction in the process of pollutant removal, the oxidation (or valence) state of the oxides of manganese sorbent is reduced from its original state during reaction with the target pollutants. For example, where the target pollutants are NO_x or SO_x , possibly through overall reactions such as the following:



In both of the reactions above, manganese (Mn) is reduced from the +4 valence state to +2 valence state during formation of the reaction products shown. It should be noted that the actual reactions may include other steps not shown, and that indicating Reactions 1 and 2 is not in any way intended to limit the scope of the invention, but is used only to illustrate the process.

Additionally, it is believed that reaction products, such as the salts of Reaction (1) and Reaction (2) above, form on the surfaces of the sorbent particles of oxides of manganese. These reactions may extend to some depth inside the sorbent particles. Applicants believe that formation of such reactions products occurs on the surfaces of the oxides of manganese particles, resulting in a layer or coating, which effectively isolates the covered portion of the particle surface and thereby prevents continued rapid reaction with additional target pollutants. Further, the oxidation state and thus the loading capacity of the oxides of manganese below the surface of the reaction product coating may be reduced during the pollutant removal, thus diminishing the loading capacity of sorbent even after the reaction product have been removed or disassociated into an aqueous solution.

Following reaction with the target pollutants, it is desirable for economic reasons to re-use the unreacted portions of the sorbent for subsequent cycles of pollutant gas removal. These unreacted portions may exhibit decreased loading capacity. In order to render reacted oxides of manganese effective for subsequent re-use as a gas sorbent with high removal efficiency, it is necessary to: (1) remove reaction products, such as salts from the sorbent particle surfaces and (2) restore or increase the target pollutant loading capacity of the oxides of manganese sorbent. Applicants have found that washing the loaded oxides of manganese in an aqueous oxidizing solution that has been adjusted to within the MnO_2 stability area can accomplish these requirements. Further, Applicants have found that loading capacity of virgin or unreacted sorbent can be increased by washing with aqueous oxidizing solutions.

Without being bound by theory, Applicants believe that the processing of oxides of manganese according to the invention in aqueous oxidizing solution systems maintained with the MnO_2 stability window may beneficially affect a number of sorbent characteristics. Such characteristics may include particle size and shape, crystalline structure or morphology,

porosity, composition, surface area, bulk density, electrochemical or oxidation potential or manganese valence states.

Regardless, the increased loading capacity is achieved with aqueous oxidizing solutions. Hypochlorites, such as sodium hypochlorite (NaOCl), have been found to be a suitable oxidizers for use in the aqueous oxidizing solutions, although many other oxidizers may also be suitable for this purpose. Other suitable oxidizers include, but are not limited to chlorates, such as sodium chlorate (NaClO_3), perchlorates such as sodium perchlorate (Na_2ClO_4), permanganates, such as potassium permanganate (KMnO_4), oxygen (O_2) or air, ozone (O_3), peroxides, such as H_2O_2 , and persulfates, such as sodium peroxodisulfate ($\text{Na}_2\text{S}_2\text{O}_8$). The electrochemical potential of the aqueous oxidizing solution, and therefore the effectiveness of the treatment methods of the invention, depends, in part, upon the strength of the oxidizer and/or the concentration of the oxidizer in the solution.

In the treatment methods and systems disclosed herein, the oxidizer used to prepare the aqueous oxidizing solution, must be able to provide the required electrochemical (oxidizing) potential (Eh), within the specified pH range, to provide an Eh-pH combination to achieve stable solution equilibrium, as defined by the MnO_2 stability area as delineated in a Pourbaix diagram, such as those depicted in Figures 9 and 10. In a Pourbaix diagram, the MnO_2 stability area is defined by the thermodynamically stable ranges or boundaries of pH-Eh combinations that promote the existence and formation MnO_2 (Mn having valence state of +4) as the most thermodynamically stable form of manganese in an aqueous solution system. The domain of MnO_2 stability for an aqueous solution varies based upon the various components of the system. For example, changes in dissolved manganese ion concentration, solution temperature, and competing dissolved ions will affect the boundaries of stability for MnO_2 . The effects of such changes upon the boundaries of the MnO_2 stability area on a Pourbaix Eh-pH diagram can be determined either by empirical data derived from experimentation or with computer software programs known to those skilled in the art, such as HSC Chemistry distributed by Outokumpu Oy of Finland. Software may also be written to determine the MnO_2 stability area as defined by other diagrams, such as the Latimer Diagram or the Frost Diagram.

In Figure 9, ranges of pH and Eh values for thermodynamically stable aqueous solutions of various manganese compounds are illustrated in graph form for aqueous solution systems at 25° C and a 1mole/liter manganese ion concentration. Figure 10 similarly illustrates ranges of pH and Eh values for aqueous solution systems at 25° C but with a 1.0 x

10^{-6} mole/liter manganese ion concentration. The Pourbaix Window diagrams depicted in Figures 9 and 10 were derived from the diagram presented in Atlas Of Electrochemical Equilibria in Aqueous Solutions," Marcel Pourbaix, pages 286-293, National Association of Corrosion Engineers, Houston, Texas.

5 The Eh and pH values as plotted on the graphs delineate the boundaries of the MnO_2 stability area for each of the two aqueous solution systems, emphasized with shading in Figures 9 and 10. A comparison of the boundaries of the two shaded areas on Figures 9 and 10 is illustrative of the different stability areas that exist under different system conditions.

10 Regardless of the specific system conditions, under the thermodynamically stable conditions for MnO_2 at a given pH and corresponding Eh range within the MnO_2 stability area or the given system conditions, the desired manganese valence state (theoretically +4) will exist. Thus, there is no propensity for Mn compounds in the +4 valence state to degrade to +3 or +2 valence states. Applicants have found that oxides of manganese treated in oxidizing solutions maintained within the MnO_2 stability area will exhibit a Mn valence state
15 of close to +4, resulting in a MnO_2 with target pollutant loading capacities equal to and/or greater than (increased) the loading capacities of virgin or loaded oxides of manganese.

20 From the graph presented in Figure 9 or 10, the thermodynamically stable ranges or boundaries of pH-Eh combinations for the particular aqueous system that will promote the existence and formation of MnO_2 can be identified. Through their understanding of the relationships between these system parameters of the MnO_2 stability area of a Pourbaix Window diagram and application thereof to conditions of a given aqueous system, Applicants are able to treat both virgin and loaded oxides of manganese sorbents so as to yield a treated sorbent, both pretreated and recycled, having equal or increased loading capacity when compared to the untreated sorbent.

25 Oxidizing solutions having the desired pH-Eh combination can be prepared, maintained or adjusted by increasing or decreasing oxidizer, acid, or base concentrations and/or temperature adjustment, as appropriate, so that the conditions are adjusted to remain within the MnO_2 stability area. With monitoring of Eh and pH data, an operator can make necessary adjustments in order to maintain or return the oxidizing solution to conditions
30 within the MnO_2 stability area. Monitoring and adjusting can also be automated utilizing electronic sensors and controllers.

Virgin (unreacted) oxides of manganese sorbent particles may be treated or pretreated to increase the oxidation state and/or target pollution loading capacity. This can be

accomplished by washing virgin (unreacted) sorbent with a wash solution of volume-to-sample weight ratio (liquid-to-solids ratio) of 2:1 or greater. However, effective treatment can also be accomplished with both lower and higher liquid-to-solids ratios as well. The sorbent powder is added to an aqueous oxidizing solution, for example a hypochlorite solution, stirred or agitated for a time sufficient to achieve an increased oxidation state and/or target pollution loading capacity. The then treated sorbent is separated by filtering, and the wet particles dried, which prepares the sorbent for target pollutant removal.

This method of virgin sorbent treatment may be better understood with reference to Figure 1. Turning to Figure 1 a virgin sorbent pretreatment system 10 is illustrated. The pretreatment system includes a washing unit 12, optionally equipped with pH probe 14 and Eh probe 16. As explained later in the specification, these probes may be utilized to provide information on aqueous solution conditions that may be utilized to provided manual or electronically controlled adjustments to relative to providing and maintaining the desire pH-Eh combination and other operating conditions. For example, temperature probe (not shown) may also optionally be provided. Virgin sorbent from virgin sorbent storage 18 is introduced into wash unit 12 along with an aqueous oxidizing solution prepared to have the desired pH-Eh combination within the MnO_2 stability area. Optionally, adjustments to the slurry pH and Eh can be made using appropriate oxidants for Eh adjustment and mineral acids and bases for pH adjustments.

The solid-liquid mixture or slurry is agitated or stirred and maintained at the desire operating conditions so as to increase the loading capacity and/or the Mn oxidation state. Optionally, adjustments to the slurry pH and Eh can be made using appropriate oxidants for Eh adjustment and mineral acids or bases for pH adjustment, so that the pH/Eh combination of the slurry is maintained within the window of MnO_2 stability for the specific system.

A filtration unit 22 configured for solid-liquid separation is next provided. Suitable filtration units known and readily identified by those skilled in the art may be utilized for filtration unit 22. The slurry from wash unit 12 is conveyed to filtration unit 22 where the treated sorbent is separated from the solution, with the wash solution or filtrate being routed for re-use, other processing or disposal. Since the filtrate may yet contain useful residual oxidizer, it may not be economic or desirable to dispose of the solution after a single use. However, after multiple uses, the solution may contain an accumulation of undesired constituents, such as contaminants and debris, that may be present in a load of virgin sorbent. Such undesired constituents may impact the efficiency or continued usefulness of the filtrate

for subsequent sorbent pretreatment. At that juncture the filtrate may be disposed of or otherwise processed to recover useful values.

In any event, the treated sorbent that has been separated from the slurry is in the form of a wet sorbent cake and may be dried prior to use in a pollutant removal system such as the Pahlman™ system if the sorbent is to be fed dry into the removal system. In some removal systems the sorbent may be fed as a slurry or even as a wet sorbent cake and for such removal systems a drying step would not be required. However, where drying is required or desired prior to introduction into a pollution removal system, the wet sorbent cake is routed to a dryer 24. A variety of dryers known to those skilled in the art may be utilized for this purpose, such as a rotary kiln, heat exchanger, oven, or other suitable dryers. After drying the treated sorbent may require comminution and possible sieving to reduce the sorbent particles to the desired size. Further, the sorbent dryer 24 may be a standard cake or slurry drying system known to those skilled in the art of drying, which could include a fluidized bed dryer or a spray dryer, configured or designed to inject the wet cake or slurry of oxides of manganese sorbent into the flow of a gas stream prior to introduction into a reaction chamber of a pollutant removal system. Whether dried and comminuted or routed to a cake or slurry drying system, the resulting sorbent having increased loading capacity is ready for use in a pollution removal system

Loaded (reacted) sorbent requires a different treatment in order to prepare it for reuse for target pollutant removal. Specifically, applicants have found it advantageous to rapidly remove the aqueous oxidizing solution from contact with the loaded sorbent being treated during washing once dissolved reaction products, such as soluble salts, have disassociated into solution. Applicants believe that such rapid removal of soluble salts is necessary in order to prevent possible re-deposition of a reaction product coating or layer, through precipitation of reaction products, e.g., sulfate and nitrate compounds or their derivatives, upon the washed oxides of manganese sorbent particles. Such coatings are believed to be detrimental to target pollutant removal efficiency of the sorbent. In order to prevent re-deposition of such coatings or layer, the washing or rinsing equipment is configured to prevent buildup of high dissolved salt concentrations and avoids prolonged sorbent contact with the wash solutions used.

Prolonged sorbent-solution contact should be avoided for another reason. As the reaction products are dissolved into solution, the acidity of the wash solution has been observed to increase, perhaps having a pH as low as 2.0-4.0, as a result of sulfate and nitrate salts, for example, combining with wash solution to form weak acids. Such pH shifts during

washing can and oxidizing of loaded sorbent can take the oxidizing solution outside of the MnO_2 stability area. At the lower pH ranges, as illustrated in the Pourbaix Window diagram of Figure 9, an upward, sometimes significant, Eh adjustment would be required to remain within the MnO_2 stability area. Base could also be added to accomplish the desired adjustment; however, this will be ineffective if the oxidizer has been depleted, requiring oxidizer addition. As some oxidizers or oxidants are inexpensive, such Eh adjustment can be uneconomic. However, if not otherwise made, a treated sorbent with a lower valence state and/or loading capacity would result. Through avoidance of prolonged contact potentially, costly Eh adjustments and pH adjustments can be avoided or minimized and a treated sorbent with increased loading capacity can be obtained.

Rapid filtration can be accomplished by various methods such as vacuum or pressure filtration. On the laboratory scale, rapid filtration can be accomplished by placing the loaded oxides of manganese sorbent to be washed on a filter media, using an apparatus such as a Buchner funnel, and maintaining a vacuum to the filter while applying the wash solution onto the loaded oxides of manganese sorbent. This results in rapid filtration of wash solutions through the sorbent, accompanied by rapid transport of dissolved salts away from the washed sorbent.

Loaded oxides of manganese sorbent samples are washed with an oxidizing wash solution of volume-to-sample weight ratio (liquid-to-solids ratio) of between 2:1 and 50:1 or greater, preferably 25:1 to 35:1. Within these liquid-to-solid ratios and with rapid filtration, effective dissolution and rapid removal of reaction products can be achieved, resulting in a treated or recycle processed (sometimes referred to as regenerated) sorbent having an increased oxidation state and/or target pollution loading capacity.

The system and method of recycle processing of loaded sorbent can be understood with reference to Figure 2. Turning to Figure 2 a loaded sorbent treatment or recycle processing system 30 is illustrated. The system 30 includes a combination rapid filtration wash unit 32. The wash unit 32 is configured to receive loaded sorbent from loaded sorbent storage 34 and to aqueous oxidizing solution. The wash unit 32 is further configured and operated so as to avoid pooling of oxidizing solution or creation of a liquefied slurry or other conditions that would lead to prolonged solid-liquid contact such that the solution no longer remains within the MnO_2 stability area. Devices such as moving belt filters presses, filter presses, and filter drum presses or pressurized or vacuum filters or other such devices

known to those skilled in the art for rapid filtration washing can be used for rapid filtration wash unit 32.

Loaded sorbent is introduced into rapid-wash filtration unit 32 from loaded sorbent storage 34. An aqueous oxidizing solution prepared to have the desired pH-Eh combination within the MnO_2 stability area is then passed over and through the loaded sorbent with rapid filtration. The aqueous oxidizing solution may be monitored and adjusted prior to application to the loaded sorbent and the Eh and pH of the filtrate may be monitored. However, monitoring is not really required as long as there is no pooling so as to cause undesirable prolonged solid-liquid contact. Once the load sorbent had been washed for a time sufficient to restore or increase the loading capacity and/or Mn oxidation state, solution is no longer applied and the wet sorbent cake is routed to dryer 36. The same types and variety of dryers suitable as dryer 24 in the virgin sorbent pretreatment system 10 are suitable for use as dryer 36 in the loaded sorbent treatment system 30. And similarly, the selection will depend upon whether the recycle processed sorbent is to be introduced into a pollutant removal system dry or as a wet sorbent cake. If to be introduced dry, with comminution and possibly sieving, as necessary, the treated or recycle processed loaded sorbent is ready for re-introduction into a pollutant removal system.

It should be noted that the embodiment of the system of the invention in Figure 2 may be utilized for treatment of virgin oxides of manganese as well, even though prolonged liquid-solid contact need not be avoided for pretreatment. Thus, virgin sorbent may be treated in the system depicted in either Figure 1 or Figure 2 and by the same method as loaded sorbent.

Respectively, Figures 7 and 8 illustrate embodiments of the invention incorporating electronic controller to provide integrated simultaneous monitoring and adjustment of operational parameters for treatment of oxides of manganese with option feed back loop for checking the loading capacity of the treated sorbent.

With reference to Figure 7, the pretreatment system 40, illustrated in block flow, has a wash unit 42, a filtration unit 44, and a dryer 46. Wash unit 42 is equipped with temperature probe 47A, pH probe 47B and Eh probe 47C which are in electronic communication with a controller 50. A vessel 52 containing oxidizing solution is configured to feed oxidizing solution to wash unit 42. Virgin sorbent vessel 53 containing virgin sorbent is configured to feed virgin sorbent to wash unit 42. Acid and/or base vessel 54 is configured to feed acid and or base to wash unit 42. The feeders (not shown) of vessels 52, 53 and 54 are in electronic

communication with the controller 50. The controller is also in electronic communication with the Eh probe 55 with which the oxidizing solution vessel 53 is equipped. As illustrated treated sorbent from dryer 46 is routed to reaction chamber 56. Alternatively, sorbent from dryer 46 may be routed for storage or to a sorbent feeder prior to introduction to the reaction chamber 56. Reaction chamber 56 represents a pollution removal system or a reaction zone of a pollution removal system such as a Pahlman™ dry removal system described in co-pending U.S. patent application numbers 09/919,600, 09/951,697, 10/044,089 and 10/025,270 or any other pollution control system that utilizes oxides of manganese as a sorbent for removal of target pollutants from gas streams. Reaction chamber 56 is equipped with optional target pollutant concentration readers or continuous emission monitors (CEMS) for NO_x and SO_x readers 57A and 57B in electronic communication with controller 50.

The controller 50 interfaces with probes 47A-47C, readers 57A, 57B and the feeders of the vessels 52-54 for measurement and adjustment of operational parameters within the pretreatment system. These parameters are important in determining the proper Eh of the aqueous oxidizing solution prior to addition to the washing unit 42 and the conditions in the washing unit 42 when the virgin sorbent is added. Eh probe 55 is in communication with controller 50 to adjust the Eh of oxidizing solution vessel 52. The controller 50 adds oxidant to vessel 52 until the desired Eh reading is obtained prior to addition to the wash unit 42. The temperature, pH, and Eh of the washing unit are monitored and adjusted so as to maintain conditions within the MnO₂ stability area.

The controller 50 contains a programmable logic controller (PLC) and other hardware components necessary for the operation of the controller such as a power supply, input and output modules that would communicate with the probes 47A-47C and/or readers 57A, 57B, and the feeders of the vessels 52-54. The controller 50 receives inputs from the various probes and readers and converts them into ladder logic language that would be used by an internal proportional integral derivative (PID) loop to individually and simultaneously monitor system operational parameters and to reconcile the inputs with predetermined or computer generated calculated set points for the operational parameters, such as temperature, and Eh and pH levels. As determined by computer logic, the controller 50 will send an output as necessary to any of the feeders of vessels 52-53 signaling a feeder to cycle on or to change feeder rate so as to maintain or adjust system operational parameters to within the MnO₂ stability area. The controller 50 may also contain an Ethernet card or other component that allows onsite or offsite remote display and operator interface and control as needed.

The controller 50 would be given a start command and direct the feeders of vessels 52 and 53 to inject, respectively, a predetermined amounts of virgin sorbent and oxidizing solution into the washing unit 42. The controller would signal the feed of a predetermined amount of oxidant into the aqueous oxidizing solution vessel checking and or adjusting the Eh and/or pH of the solution prior to feeding into the washing unit. The Eh of the oxidizing solution in vessel 52 may be adjusted by addition of an oxidizer in sufficient quantity as to raise the Eh to the desired level from an oxidizer vessel, not shown in Figure 7, containing a supply of oxidizer. As determined by programmed controller logic, the controller 50 would also check, based on inputs received from the probes 47A-47C and/or adjust the conditions of the washing unit by adjusting the temperature utilizing a heater or heat exchanger (not shown in Figure 7) to increase or decrease solution temperature; the pH, if needed, by increasing or decreasing the rate of base or acid feed; and the Eh, if needed, by increasing or decreasing the oxidizer concentration of the aqueous oxidizing solution. An optional, final quality control loop may be provided utilizing the readers 57A, 57B checking the loading performance of the treated sorbent by sending, for example, SO_x and NO_x readings back to the controller 50. As determined by controller logic, the controller 50 would then adjust the washing unit parameters, if needed, to provide treated oxides of manganese having increased loading capacity as compared to the untreated virgin sorbent contained in vessel 53. The same controller may also be used to control the entire operation of both the reaction chamber 56 and the pretreatment system 40, or separate controllers may be provided.

With reference to Figure 8, a recycle processing or regeneration system 60, for treating loaded sorbent is illustrated as a block flow diagram. The regeneration system 60 has a rapid filtration wash unit 62 from which treated sorbent is routed to dryer 64. The filtrate from wash unit 62 is directed for disposal or for other processing to recover useful values therein. Loaded sorbent vessel 66 is configured to feed loaded sorbent to wash unit 62. An oxidizing solution vessel 68 containing oxidizing solution is configured to feed oxidizing solution to wash unit 62. The feeders (not shown) of vessels 66, 68 are in electronic communication with the controller 70. Vessel 68 is equipped with an Eh probe 72A and pH probe 72B which are also in electronic communication with the controller 70. As illustrated, treated sorbent from the dryer 64 is routed to a reaction chamber 56. It being understood that, as in pretreatment system of Figure 7, the treated sorbent may be routed to a sorbent feeder or to a sorbent storage bin. Similarly, optional readers 57A, 57B are in electronic

communication with controller 70, providing a optional control loop to check loading performance of treated sorbent.

The controller 70 interfaces with the Eh probe 72A, pH probe 72B, temperature probe 72C, the readers 57A, 57B, and the feeders of the vessels 66, 68 to monitor and adjust the operational parameters of pH, Eh and temperature within the regeneration system 60. Additionally, the controller 70 interfaces with a vessel (not shown in Figure 8) and the feeder thereof to provide acid or base as necessary to the aqueous oxidizing solution. It is important to determine and adjust, as necessary, the operational parameters prior to introducing the oxidizing solution into wash unit 62 in order to assure that conditions of the oxidizing solution are within the MnO_2 stability area.

The controller 70 contains a programmable logic controller (PLC) and other components that would be necessary for the operation of the controller such as a power supply, input and output modules that would communicate with the probes 72A, 72B, 72C, the readers 57A, 57B and the feeders that supply the loaded sorbent, the aqueous oxidizing solution, and acid or base. The controller 70 receives inputs from the various probes and readers and convert them into ladder logic language that would be used by the internal proportional integral derivative (PID) loop to individually or simultaneously monitor system operational parameters and to reconcile the inputs with predetermined or computer generated calculated set points for the operational parameters. The controller 70 may also contain an Ethernet card or other component that allows onsite or offsite remote display and operator interface and control as needed. Such integrated control of the regeneration system allows a practical alternative to manual adjustments by an operator and lends itself to automation of the regeneration system even from remote locations.

The controller 70 would be given a start command and signal the feeders of the vessels 66, 68, simultaneously or in desired sequence, to inject a predetermined amount of loaded sorbent and oxidizing solution into rapid filtration wash unit 62. In order to maintain conditions of the solution within the MnO_2 stability area, the controller 70 would, as necessary, signal feed of a predetermined amount of oxidizer, acid or base into the aqueous oxidizing solution in vessel 68, regularly monitoring and/or adjusting the Eh and/or pH of the solution prior to being fed into the washing unit. As determined by the controller logic, the controller 70 would also check, based on inputs received from the probes 72A, 72B, 72C, and/or adjust the conditions of the aqueous oxidizing solution in vessel 68 by adjusting the temperature utilizing a heater or heat exchanger (not shown in Figure 8) to increase or

decrease solution temperature; the pH, if needed, by increasing or decreasing the rate of base or acid feed; and the Eh, if needed, by increasing or decreasing the oxidizer concentration of the aqueous oxidizing solution.

As in the pretreatment system, an optional, final quality control loop may be provided utilizing the readers 57A, 57B, checking the loading performance of the treated sorbent by sending, for example, SO_x and NO_x readings back to the controller 70. As determined by controller logic, the controller 70 would then adjust oxidizing solution parameters, if needed, to provide treated oxides of manganese having increased loading capacity as compared to the untreated loaded sorbent contained in vessel 66. The same controller may also be used to control the entire operation of both the reaction chamber 56 and the treatment system 40, or separate controllers may be provided.

Applicants conducted a series of lab-scale tests utilizing a live slipstream of an actual exhaust gas from a coal-fired combustion source in order to demonstrate the increased loaded capacity achieved with the invention. A glass reactor designed to mimic the gas-solid interactions known to be present in the reaction zones of a Pahlman™ dry target pollutant removal system was utilized for the tests. The glass reactor was a vertically positioned Pyrex™ glass cylinder having an internal diameter of 2 inches and a length of approximately 18 inches. For each test run, 50.0 grams of oxides of manganese were suspended in the reactor using a permeable fritted glass filter positioned approximately 4 inches from the bottom of the reactor, allowing for flow of the gas stream through the reactor while keeping the oxides of manganese suspended. The test reactor was insulated and configured with thermocouples for temperature readings and heating elements for temperature control to maintain a temperature set point, which in the purposes of the conducted testes was 250°F.

A NO_x and SO₂ laden gas stream was pumped into the bottom of the test reactor at a flow rate which provided adequate fluidization of the bed of sorbent to promote optimal gas/solids contact. The reactor was heated during the testing to 250°F and the gas flow rate was metered at a constant 6.5 liters per minute (lpm). The slipstream of actual exhaust gas was from a 570 MW tangentially-fired coal-burning boiler operating on Powder River Basin (PRB) western coal.

The composition of the exhaust gas was measured both on the inlet and outlet of the test reactor with appropriate gas analyzers, as one skilled in the art would employ and for the test run examples presented found to be within the following ranges: Oxygen (O₂) 6-7%, carbon dioxide (CO₂) 10-12%, oxides of nitrogen (NO_x) 190-250ppm, sulfur dioxide (SO₂)

400-500ppm. The composition of the inlet gas to the test reactor varied slightly from test to test, therefore the data was normalized and presented as pounds (lbs) of NO_x or SO₂ into and out of the test reactor. The extent of NO_x and SO₂ loading was then calculated to determine the effectiveness of the aqueous oxidizing rinse. The slipstream was passed through the fluidized bed of oxides of manganese, where the flow carried a portion of the sorbent up onto the filter, thus creating a filter cake, which mimics a bag house reaction chamber of a Pahlman™ dry target pollutant removal system.

SO₂ and NO_x concentrations were measured continuously alternating from the reactor inlet and outlet utilizing a continuous emissions monitoring system (CEMS). SO₂ concentrations were measured utilizing a Bovar Western Research model 921NMP spectrophotometric instrument and NO_x concentrations were measured utilizing a Thermo Electron model 42H chemiluminescent instrument. In order to obtain accurate and reliable emission concentrations, sampling and reporting was conducted in accordance with US EPA Reference CFR 40, Part 60, Appendix A, Method 6C. Inlet gas temperature was 250° F, with a differential pressure across the permeable fritted glass filter was 2.00" of WC. Figures 3 and 4 show the results of comparative test runs conducted utilizing 50g of each of virgin EMD type oxides of manganese sorbent, to provide a baseline, and treated virgin EMD type oxides of manganese sorbent prepared according to the invention. The treated virgin EMD type oxides of manganese sorbent sample was prepared by first treating with an aqueous oxidizing solution of 0.01% sodium hypochlorite (NaOCl). The measured pH and Eh values of the starting aqueous oxidizing solution of 0.01% sodium hypochlorite (NaOCl) were 8.5 and 900mV respectively, which provided a solution within the MnO₂ stability area. A quantity of virgin EMD type oxides of manganese sorbent (75.3g) was then added to a mixing beaker of 151g of the aqueous oxidizing solution of 0.01% sodium hypochlorite (NaOCl). The slurry was then continually stirred for a period of 15 minutes while recording data on the changing pH and Eh of the solution. The starting pH of 8.5 quickly dropped to 6.2 within the first minute of mixing and after 15 minutes had dropped to 6.1. The Eh which started at 900mV rose to 1040mV within the first minute of mixing then started slowly dropping in about even increments to a final value of 885mV after 15 minutes. The slurry was then placed in a paper filter to separate the solids from the filtrate. The now treated EMD type oxides of manganese sorbent was then placed in a drying oven and dried for 5 hrs at 185°F (85°C). The dried sorbent was then gently deagglomerated and 50g were then placed in the laboratory test reactor for subsequent target pollutant loading, the measured data points

are plotted and identified in Figures 3 and 4 as "Virgin Sorbent Following Treatment".

Along with the treated virgin EMD type sorbent loading rates, data points from untreated virgin EMD type oxides of manganese sorbent are also plotted in Figure 3 and 4 as "Virgin Sorbent Baseline" to provide a baseline for loading capacity comparison.

5 Figure 3 shows the NO_x loading curves. Looking at the virgin sorbent baseline, the virgin EMD type sorbent was at least achieving 90% NO_x removal on a ppm basis for 24 minutes, during which time an accumulative total of 158×10^{-6} pounds of NO_x entered into the laboratory test reactor with only 5.6×10^{-6} pounds of NO_x exiting the reactor, for a total of 152.4×10^{-6} pounds of NO_x being captured by the virgin EMD type oxides of manganese
10 sorbent. The treated virgin EMD type sorbent is shown to exhibit substantially improved loading rates. NO_x removal time at a NO_x removal rate of at least 90% was increased to 47 minutes. For comparison, an accumulative total of 331×10^{-6} pounds of NO_x entered the laboratory test reactor with only 6.1×10^{-6} pounds of NO_x exiting the reactor for a total of 324.9×10^{-6} pounds of NO_x being captured by the treated virgin EMD type oxides of
15 manganese sorbent

Figure 4 shows the SO₂ loading curves. Looking at the virgin sorbent baseline, the virgin EMD type sorbent was at least achieving 99% SO₂ removal on a ppm basis for 24 minutes, during which time an accumulative total of 548×10^{-6} pounds of SO₂ entered into the laboratory test reactor with only 1.9×10^{-6} pounds of SO₂ exiting the reactor, for a total of
20 546.1×10^{-6} pounds of SO₂ being captured by the virgin EMD type oxides of manganese sorbent. The treated virgin EMD type sorbent is shown to exhibit substantially improved loading rates. SO₂ removal time at a removal rate of at least 99% was increased to 61 minutes. For comparison, an accumulative total of 1266×10^{-6} pounds of SO₂ entered the laboratory test reactor with only 0.9×10^{-6} pounds of SO₂ exiting the reactor, for a total of
25 1265.1×10^{-6} pounds of SO₂ being captured by the treated virgin EMD type oxides of manganese sorbent.

Figures 5 and 6 show the results of comparative test runs conducted utilizing 50g of each of virgin EMD type oxides of manganese sorbent, to provide a baseline, and treated loaded EMD type oxides of manganese sorbent prepared according to the invention. The
30 treated loaded EMD type sorbent sample was first treated with an aqueous oxidizing solution of 0.01% sodium hypochlorite (NaOCl). The measured pH and Eh values of the starting aqueous oxidizing solution of 0.01% sodium hypochlorite (NaOCl) were 8.9 and 900mV respectively, which provided a solution within the MnO₂ stability area. A quantity of loaded

EMD type oxides of manganese sorbent (98.8g) was evenly distributed on moistened filter paper, which was placed in a Beuchner funnel. After applying vacuum, a first quantity of 1650 ml of aqueous oxidizing solution of 0.01% sodium hypochlorite (NaOCl) was evenly applied to the loaded EMD type sorbent surface at a rate such that no solution pooling was allowed to take place. The filtrate was then collected and the pH and Eh was measured to be 2.8 and 1070mV respectively. A second quantity of 1650 ml of an aqueous oxidizing solution of 0.01% sodium hypochlorite (NaOCl) was again evenly applied to the loaded sorbent surface at a rate such that no solution pooling was allowed to take place. The second filtrate was then found to have a pH of 2.8 and an Eh of 1100mV. The now treated EMD type oxides of manganese sorbent was then placed in a drying oven and dried for 2 hrs at 185°F (85°C). The dried sorbent was then gently deagglomerated and 50g were then placed in the laboratory test reactor for subsequent target pollutant loading, the measured data points are plotted and identified in Figures 5 and 6 as "Loaded Sorbent Following Treatment." The data points from untreated virgin EMD type oxides of manganese sorbent are plotted in Figure 5 and 6 as "Virgin Sorbent Baseline" to provide a baseline for loading capacity comparison.

Figure 5 shows the NO_x loading curves. Looking at the virgin sorbent baseline, the EMD type sorbent was at least achieving 90% NO_x removal on a ppm basis for 24 minutes, during which time an accumulative total of 158×10^{-6} pounds of NO_x entered into the laboratory test reactor with only 5.6×10^{-6} pounds of NO_x exiting the reactor, for a total of 152.4×10^{-6} pounds of NO_x being captured by the virgin EMD type oxides of manganese sorbent. The loaded EMD type sorbent following treatment is shown to exhibit substantially improved loading rates. NO_x removal time at a removal rate of at least 90% was increased to 32 minutes. For comparison, an accumulative total of 222×10^{-6} pounds of NO_x entered the laboratory test reactor with 8.4×10^{-6} pounds of NO_x exiting the reactor, for a total of 213.6×10^{-6} pounds of NO_x being captured by the treated loaded EMD type oxides of manganese sorbent.

Figure 6 shows the SO₂ loading curves. Looking at the virgin sorbent baseline, the EMD type sorbent was at least achieving 99% SO₂ removal on a ppm basis for 24 minutes, during which time an accumulative total of 548×10^{-6} pounds of SO₂ entered into the laboratory test reactor with only 1.9×10^{-6} pounds of SO₂ exiting the reactor, for a total of 546.1×10^{-6} pounds of SO₂ being captured by the virgin EMD type oxides of manganese sorbent. The treated loaded EMD type sorbent is shown to exhibit substantially improved

loading rates. SO₂ removal time at a rate of at least 99% was increased to 47 minutes. For comparison, an accumulative total of 901×10^{-6} pounds of SO₂ entered the laboratory test reactor with only 3.2×10^{-6} pounds of SO₂ exiting the reactor, for a total of 897.8×10^{-6} pounds of SO₂ being captured by the treated loaded EMD type oxides of manganese sorbent.

5 The data from the lab-scale tests presented in Figure 3-6 illustrate the increased loading capacity that is achievable with the invention.

 While exemplary embodiments of this invention and methods of practicing the same have been illustrated and described, it should be understood that various changes, adaptations, and modifications might be made therein without departing from the spirit of the
10 invention and the scope of the appended claims.

WHAT IS CLAIMED IS:

1. A process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of:
 - a. washing virgin oxides of manganese in wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area ; and
 - b. filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.
2. A process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of:
 - a. washing virgin oxides of manganese in a wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area ;
 - b. monitoring and adjusting the pH and/or the Eh values of the solution so as to maintain the Eh and pH values of the solution within the MnO_2 stability area; and
 - c. filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.
3. A process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of:
 - a. washing virgin oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution to form a filtrate and a pretreated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area; and
 - b. removing the pretreated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.

4. A process for regeneration of loaded oxides of manganese formed through reaction between unreacted oxides of a manganese and target pollutants in a gas stream, comprising the steps of:
- washing loaded oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution having Eh and pH values within the MnO_2 stability area to form a filtrate and a regenerated oxides of manganese filter cake; and
 - removing the regenerated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese from which the loaded oxides of manganese are formed.
5. A process for regeneration of loaded oxides of manganese sorbent particles bearing a reaction product layer of the surface thereof formed during reaction between unreacted oxides of manganese sorbent particles and target pollutants in a gas stream in a pollution removal system, comprising the steps of :
- rapidly washing and filtering the loaded oxides of manganese sorbent particles in a rapid filtration wash unit with an aqueous oxidizing solution to dissolve the reaction product layer from the surface of the loaded oxides of manganese sorbent particles into the solution to form a filtrate and a regenerated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area; and
 - removing the regenerated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese sorbent particles from which the loaded oxides of manganese sorbent particles are formed.
6. The process of any one of claims 1 to 5, further comprising the steps of:
drying the filter cake; and
comminuting and sizing the dried filter cake to provide oxides of manganese particles.
7. The process of any one of claims 1 to 5, further comprising the steps of:
drying the filter cake;

comminuting and sizing the dried filter cake to provide oxides of manganese particles for introduction into a feeder or reaction chamber of a dry pollution removal system.

8. The process of any one of claims 1 to 5, further comprising the steps of:
drying the filter cake;
comminuting and sizing the dried filter cake to provide oxides of manganese particles for introduction into a feeder or reaction chamber of a dry pollution removal system; and
introducing the comminuted and sized oxides of manganese particles into the feeder or reaction chamber.
9. The process of any one of claims 1-5, further comprising the step of:
conveying the filter cake to a dryer configured to inject the a wet filter cake or a slurry of oxides of manganese sorbent into the flow of a gas stream prior to introduction into a reaction chamber of a pollutant removal system.
10. The process of any one of claims 1-5, further comprising the steps of:
conveying the filter cake to a dryer configured to inject the a wet filter cake or a slurry of oxides of manganese sorbent into the flow of a gas stream prior to introduction into a reaction chamber of a pollutant removal system; and
injecting the wet filter cake or the slurry into the reaction chamber.
11. The process of claim 2, wherein the monitoring and adjusting step is carried out by a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control of within the wash unit of the temperature, Eh values, and pH values in order to maintain conditions of the aqueous oxidizing solution within the MnO₂ stability area.
12. The process of anyone of claims 1-5, , wherein the aqueous oxidizing solution contains an oxidizer selected from the group consisting of hypochlorites, chlorates, perchlorates, permanganates, oxygen (O₂), air, ozone, peroxides, persulfates, and combinations thereof.

13. A system for pretreatment of virgin oxides of manganese, comprising:

- a. wash unit configured to hold and agitate a slurry of virgin oxides of manganese in an aqueous oxidizing solution, the solution have Eh and pH values within the MnO_2 stability area, the wash unit being optionally equipped with a pH probe, an Eh probe, and a temperature probe, the wash unit being further configured to receive the slurry of virgin oxides of manganese or to individually receive virgin oxides of manganese and the aqueous oxidizing solution;
- b. a filtration unit configured to receive the slurry from the wash unit and to filter the slurry to form a filtrate and a pretreated oxides of manganese filter cake;
- c. an aqueous oxidizing solution vessel containing a supply of aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area, the vessel having a feeder configured to feed aqueous oxidizing solution to the wash unit and being optionally equipped with an Eh probe;
- d. an oxides of manganese vessel containing a supply of virgin oxides of manganese, the vessel having a feeder configured to feed oxides of manganese directly to the wash unit or, in conjunction with the aqueous oxidizing solution feeder to feed a slurry of virgin oxides of manganese to the wash unit; and
- e. a pH adjust vessel having a supply of acid or base or separate supplies of acid and base, the pH adjust vessel having a feeder configured to feed acid and/or base to the wash unit.

14. A system for treatment of virgin or loaded oxides of manganese, comprising:

- a. a rapid filtration wash unit, the wash unit being configured to individually receive oxides of manganese and an aqueous oxidizing solution having a Eh and pH values within the MnO_2 stability area, the wash unit being further configured to rapidly remove the aqueous oxidizing solution from contact with the oxides of manganese forming a filtrate and a treated oxides of manganese filter cake;
- b. an aqueous oxidizing solution vessel containing a supply of aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area, the vessel having a feeder configured to feed aqueous oxidizing solution to the wash unit and being optionally equipped with a probe selected from the group consisting of an Eh probe, a pH probe, a temperature probe, or any combination thereof;

c. an oxides of manganese vessel containing a supply of virgin or loaded oxides of manganese, the vessel having a feeder configured to feed oxides of manganese to the wash unit; and

d. optionally, a oxidizer vessel containing a supply of oxidizer, the oxidizer vessel having feeder configured to feed oxidizer to the aqueous oxidizing solution vessel; and

e. optionally, a pH adjust vessel having a supply of acid or base or separate supplies of acid and base, the pH adjust vessel having a feeder configured to feed acid and/or base to the aqueous oxidizing solution vessel.

15. The system of claim 13, further comprising

a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control within the wash unit of the temperature, Eh values, and pH values in order to maintain conditions of the aqueous oxidizing solution within the MnO_2 stability area.

16. The system of claim 14, further comprising

a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control of the temperature, Eh values, and pH values within the aqueous oxidizing solution vessel in order to maintain conditions of the aqueous oxidizing solution within the MnO_2 stability area.

17. A system for pretreatment of virgin oxides of manganese, comprising:

a. a wash unit configured to hold and agitate a slurry of virgin oxides of manganese in an aqueous oxidizing solution, the solution have Eh and pH values within the MnO_2 stability area, the wash unit being equipped with a pH probe, an Eh probe, and a temperature probe, the wash unit being further configured to receive the slurry of virgin oxides of manganese or to individually receive virgin oxides of manganese and the aqueous oxidizing solution;

b. a filtration unit configured to receive the slurry from the wash unit and to filter the slurry to form a filtrate and a pretreated oxides of manganese filter cake;

c. an aqueous oxidizing solution vessel containing a supply of aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area, the vessel having

a feeder configured to feed aqueous oxidizing solution to the wash unit and being equipped with an Eh probe;

d. an oxides of manganese vessel containing a supply of virgin oxides of manganese, the vessel having a feeder configured to feed oxides of manganese directly to the wash unit or, in conjunction with the aqueous oxidizing solution feeder to feed a slurry of virgin oxides of manganese to the wash unit;

e. a pH adjust vessel having a supply of acid or base or separate supplies of acid and base, the pH adjust vessel having a feeder configured to feed acid and/or base to the wash unit;

f. a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control within the wash unit of the temperature, Eh values, and pH values in order to maintain conditions of the aqueous oxidizing solution within the MnO_2 stability area, the controller being electronic communication with the probes and feeders of the system..

18. A system for treatment of virgin or loaded oxides of manganese, comprising:

a. a rapid filtration wash unit, the wash unit being configured to individually receive oxides of manganese and an aqueous oxidizing solution having a Eh and pH values within the MnO_2 stability area, the wash unit being further configured to rapidly remove the aqueous oxidizing solution from contact with the oxides of manganese forming a filtrate and a treated oxides of manganese filter cake;

b. an aqueous oxidizing solution vessel containing a supply of aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area, the vessel having a feeder configured to feed aqueous oxidizing solution to the wash unit and being equipped with a probe selected from the group consisting of an Eh probe, a pH probe, a temperature probe, or any combination thereof;

c. an oxides of manganese vessel containing a supply of virgin or loaded oxides of manganese, the vessel having a feeder configured to feed oxides of manganese to the wash unit;

d. a oxidizer vessel containing a supply of oxidizer, the oxidizer vessel having feeder configured to feed oxidizer to the aqueous oxidizing solution vessel;

e. a pH adjust vessel having a supply of acid or base or separate supplies of acid and base, the pH adjust vessel having a feeder configured to feed acid and/or base to the aqueous oxidizing solution vessel; and

f. a controller capable of individually or simultaneously monitoring and adjusting system operational parameters, the controller providing integrated control of the temperature, Eh values, and pH values within the aqueous oxidizing solution vessel in order to maintain conditions of the aqueous oxidizing solution within the MnO_2 stability area, the controller being in electronic communication with the probes and feeders of the system.

19. The system of any one of claims 13, 14, 17, or 18, wherein the aqueous oxidizing solution contains an oxidizer selected from the group consisting of hypochlorites, chlorates, perchlorates, permanganates, oxygen (O_2), air, ozone, peroxides, persulfates, and combinations thereof.

20. The system of claim 15, further comprising,
a dryer for drying the filter cake;

a device for comminuting and sizing the dried filter cake to form oxides of manganese particles;

a reaction chamber of a pollutant removal system into which the oxides of manganese particles are introduced to capture target pollutants from a gas, the reaction chamber being equipped with at least one target pollutant concentration reader for measuring target pollutant concentration of the gas as it exits the reaction chamber, the reader being in electronic communication with the controller for checking the loading performance of the oxides of manganese particles and signaling need for adjustment of operational parameters within the wash unit.

21. The system of claim 16, further comprising:

a dryer for drying the filter cake;

a device for comminuting and sizing the dried filter cake to form oxides of manganese particles;

a reaction chamber of a pollutant removal system into which the oxides of manganese particles are introduced to capture target pollutants from a gas, the reaction chamber being equipped with at least one target pollutant concentration reader for measuring target pollutant concentration of the gas as it exits the reaction chamber, the reader being in electronic communication with the controller for checking the loading performance of the oxides of manganese particles and signaling need for adjustment of operational parameters within the aqueous oxidizing solution vessel.

22. The system of claim 17, further comprising,

a dryer for drying the filter cake;

a device for comminuting and sizing the dried filter cake to form oxides of manganese particles;

a reaction chamber of a pollutant removal system into which the oxides of manganese particles are introduced to capture target pollutants from a gas, the reaction chamber being equipped with at least one target pollutant concentration reader for measuring target pollutant concentration of the gas as it exits the reaction chamber, the reader being in electronic communication with the controller for checking the loading performance of the oxides of manganese particles and signaling need for adjustment of operational parameters within the wash unit.

23. The system of claim 18, further comprising:

a dryer for drying the filter cake;

a device for comminuting and sizing the dried filter cake to form oxides of manganese particles;

a reaction chamber of a pollutant removal system into which the oxides of manganese particles are introduced to capture target pollutants from a gas, the reaction chamber being equipped with at least one target pollutant concentration reader for measuring target pollutant concentration of the gas as it exits the reaction chamber, the reader being in electronic communication with the controller for checking the loading performance of the oxides of manganese particles and signaling need for adjustment of operational parameters within the aqueous oxidizing solution vessel.

24. Oxides of manganese particles formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of:

- a. washing virgin oxides of manganese in wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area ;
- b. filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese;
- c. drying the filter cake; and
- d. comminuting and sizing the dried filter cake to form oxides of manganese particles.

25. Oxides of manganese particles formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of:

- a. washing virgin oxides of manganese in a wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area ;
- b. monitoring and adjusting the pH and/or the Eh values of the solution so as to maintain the Eh and pH values of the solution within the MnO_2 stability area;
- c. filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese;
- d. drying the filter cake; and
- e. comminuting and sizing the dried filter cake to form oxides of manganese particles.

26. Oxides of manganese particles formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of:

- a. washing virgin oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution to form a filtrate and a pretreated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area;
- b. removing the pretreated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese;
- c. drying the filter cake; and
- d. comminuting and sizing the dried filter cake to form oxides of manganese particles.

27. Oxides of manganese particles formed by a process for regeneration of loaded oxides of manganese formed through reaction between unreacted oxides of a manganese and target pollutants in a gas stream, comprising the steps of:

- a. washing loaded oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution having Eh and pH values within the MnO_2 stability area to form a filtrate and a regenerated oxides of manganese filter cake;
- b. removing the regenerated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese from which the loaded oxides of manganese are formed;
- c. drying the filter cake; and
- d. comminuting and sizing the dried filter cake to form oxides of manganese particles.

28. Oxides of manganese sorbent particles formed by a process for regeneration of loaded oxides of manganese sorbent particles bearing a reaction product layer of the surface thereof formed during reaction between unreacted oxides of manganese sorbent particles and target pollutants in a gas stream in a pollution removal system, comprising the steps of:

- a. rapidly washing and filtering the loaded oxides of manganese sorbent particles in a rapid filtration wash unit with an aqueous oxidizing solution to dissolve the reaction product layer from the surface of the loaded oxides of manganese sorbent particles into the solution to

form a filtrate and a regenerated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area;

- b. removing the regenerated oxides of manganese filter cake from the rapid filtration unit, the oxides of manganese of the filter cake having a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese sorbent particles from which the loaded oxides of manganese sorbent particles are formed;
- c. drying the filter cake; and
- d. comminuting and sizing the dried filter cake to form oxides of manganese particles.

29. The oxides of manganese particles formed by the process of anyone of claims 24-28, wherein the aqueous oxidizing solution contains an oxidizer selected from the group consisting of hypochlorites, chlorates, perchlorates, permanganates, oxygen (O_2), air, ozone, peroxides, persulfates, and combinations thereof.

30. Oxides of manganese filter cakes particles formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the steps of:

- a. washing virgin oxides of manganese in a wash unit with an aqueous oxidizing solution, the solution having Eh and pH values within the MnO_2 stability area ;
- b. monitoring and adjusting the pH and/or the Eh values of the solution so as to maintain the Eh and pH values of the solution within the MnO_2 stability area; and
- c. filtering the washed oxides of manganese to form a filtrate and a pretreated oxides of manganese filter cake, the oxides of manganese of the filter cake having a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.

31. Oxides of manganese filter cake formed by a process for pretreatment of virgin oxides of manganese for use as a sorbent to remove target pollutants from a gas stream, comprising the step of:

washing virgin oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution to form a filtrate and a pretreated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area;

wherein the oxides of manganese of the pretreated oxides of manganese filter cake have a pollutant loading capacity greater than the pollutant loading capacity of the virgin oxides of manganese.

32. Oxides of manganese filter cake formed by a process for regeneration of loaded oxides of manganese formed through reaction between unreacted oxides of a manganese and target pollutants in a gas stream, comprising the step of:

washing loaded oxides of manganese in a rapid filtration wash unit with an aqueous oxidizing solution having Eh and pH values within the MnO_2 stability area to form a filtrate and a regenerated oxides of manganese filter cake;

wherein the oxides of manganese of the regenerated oxides of manganese filter cake have a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese from which the loaded oxides of manganese are formed.

33. Oxides of manganese filter cake formed by a process for regeneration of loaded oxides of manganese sorbent particles bearing a reaction product layer of the surface thereof formed during reaction between unreacted oxides of manganese sorbent particles and target pollutants in a gas stream in a pollution removal system, comprising the step of:

rapidly washing and filtering the loaded oxides of manganese sorbent particles in a rapid filtration wash unit with an aqueous oxidizing solution to dissolve the reaction product layer from the surface of the loaded oxides of manganese sorbent particles into the solution to form a filtrate and a regenerated oxides of manganese filter cake, the solution having Eh and pH values within the MnO_2 stability area;

wherein the oxides of manganese in the regenerated oxides of manganese filter cake have a pollutant loading capacity equal to or greater than the pollutant loading capacity of the unreacted oxides of manganese sorbent particles from which the loaded oxides of manganese sorbent particles are formed.

34. The filter cakes of anyone of claims 30-33, wherein the aqueous oxidizing solution contains an oxidizer selected from the group consisting of hypochlorites, chlorates, perchlorates, permanganates, oxygen (O₂), air, ozone, peroxides, persulfates, and combinations thereof.

FIGURE 1
TREATMENT OF VIRGIN OXIDES OF MANGANESE SORBENT

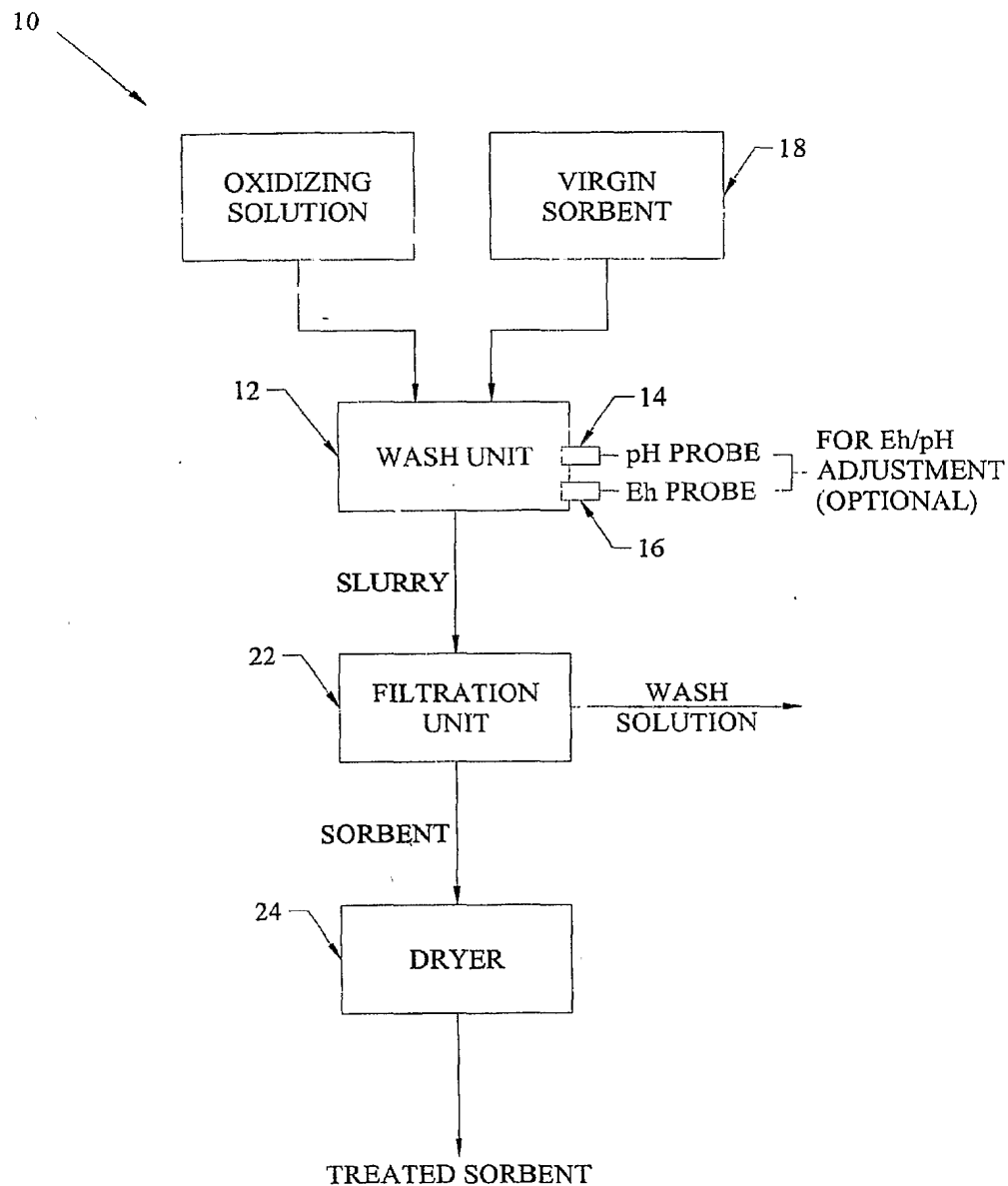


FIGURE 2
TREATMENT OF LOADED OXIDES OF MANGANESE SORBENT

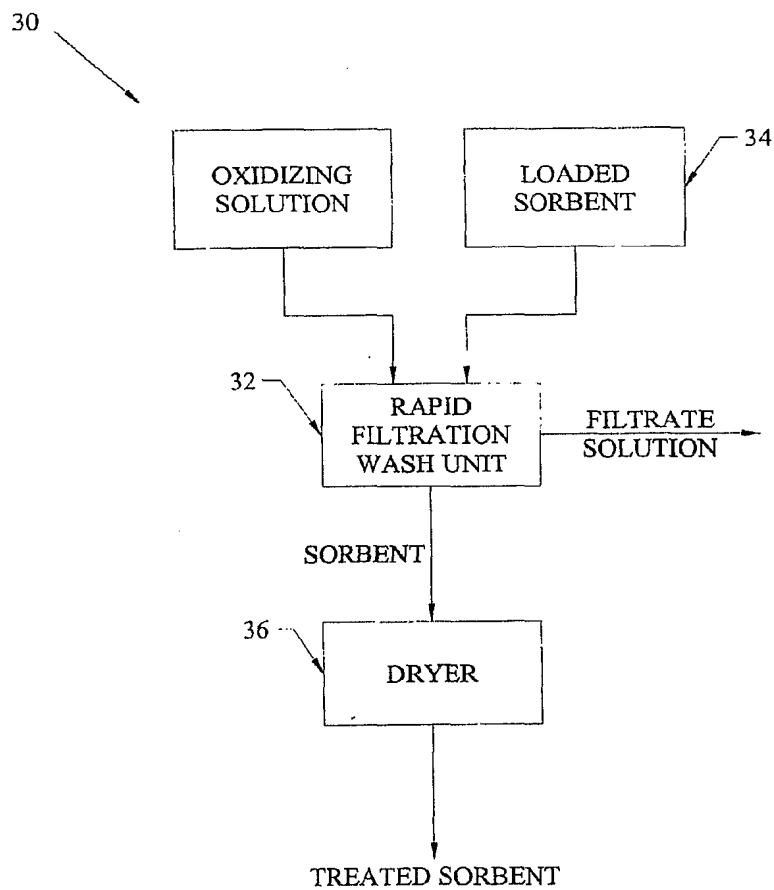


Figure 3
NO_x Loading of Virgin Unreacted Oxides of Manganese Sorbent Following Treatment
with an Oxidizing Aqueous Rinse as Defined in Applicants Invention.

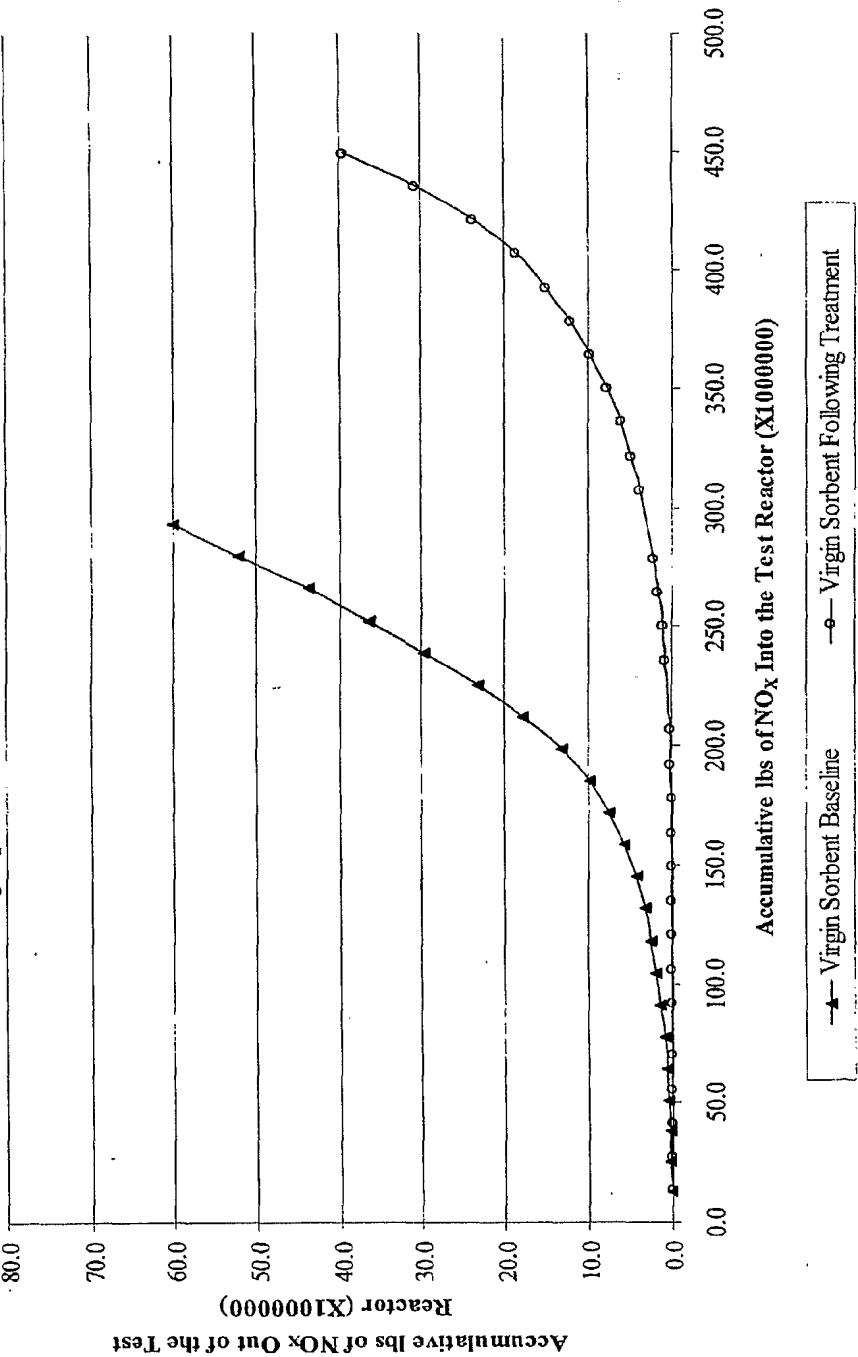


Figure 4
SO_x Loading of Virgin Unreacted Oxides of Manganese Sorbent Following Treatment
with an Oxidizing Aqueous Rinse as Defined in Applicants Invention.

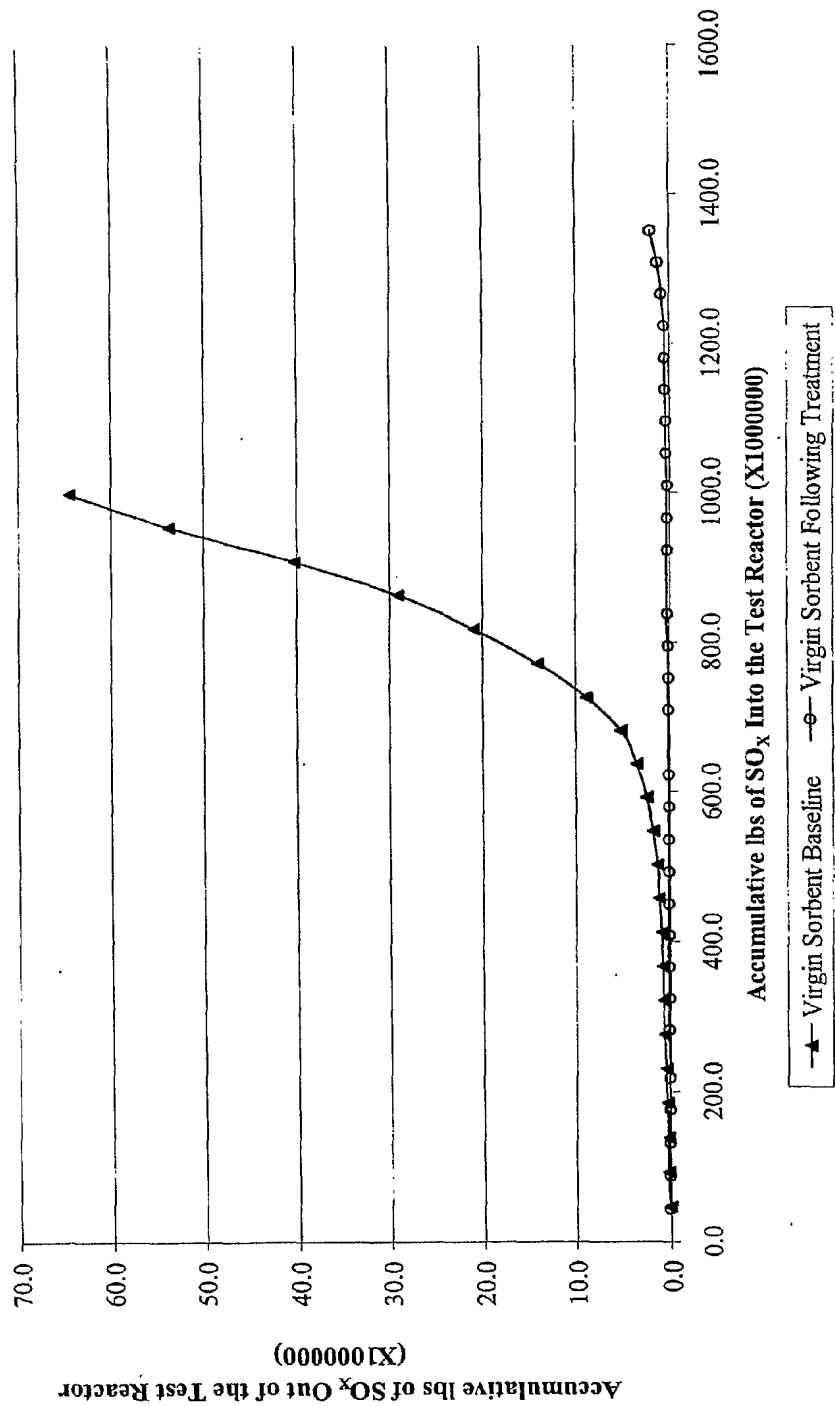


Figure 5
NO_x Loading of Previously Loaded Oxides of Manganese Sorbent Following Treatment
with an Oxidizing Aqueous Rinse as Defined in Applicants Invention.

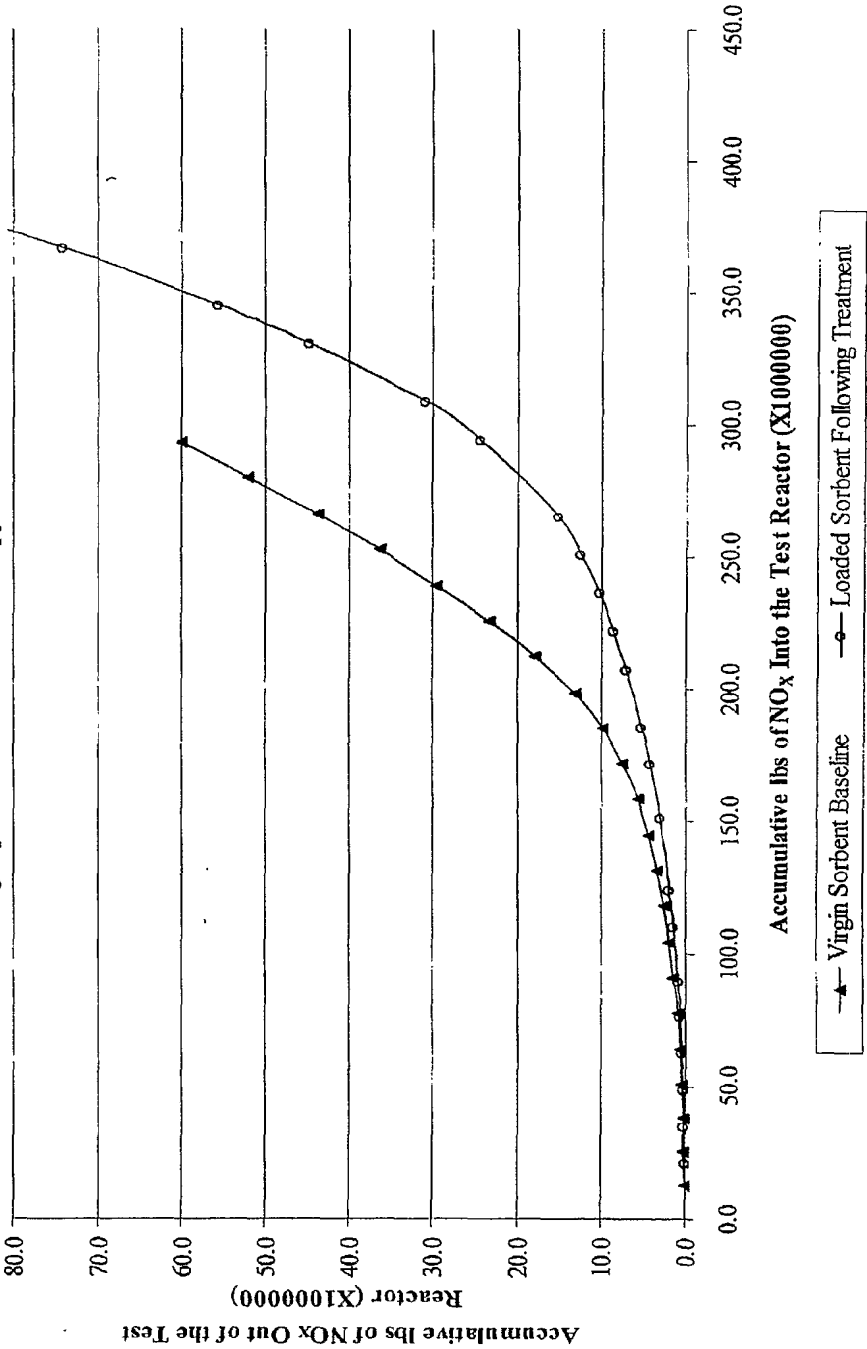
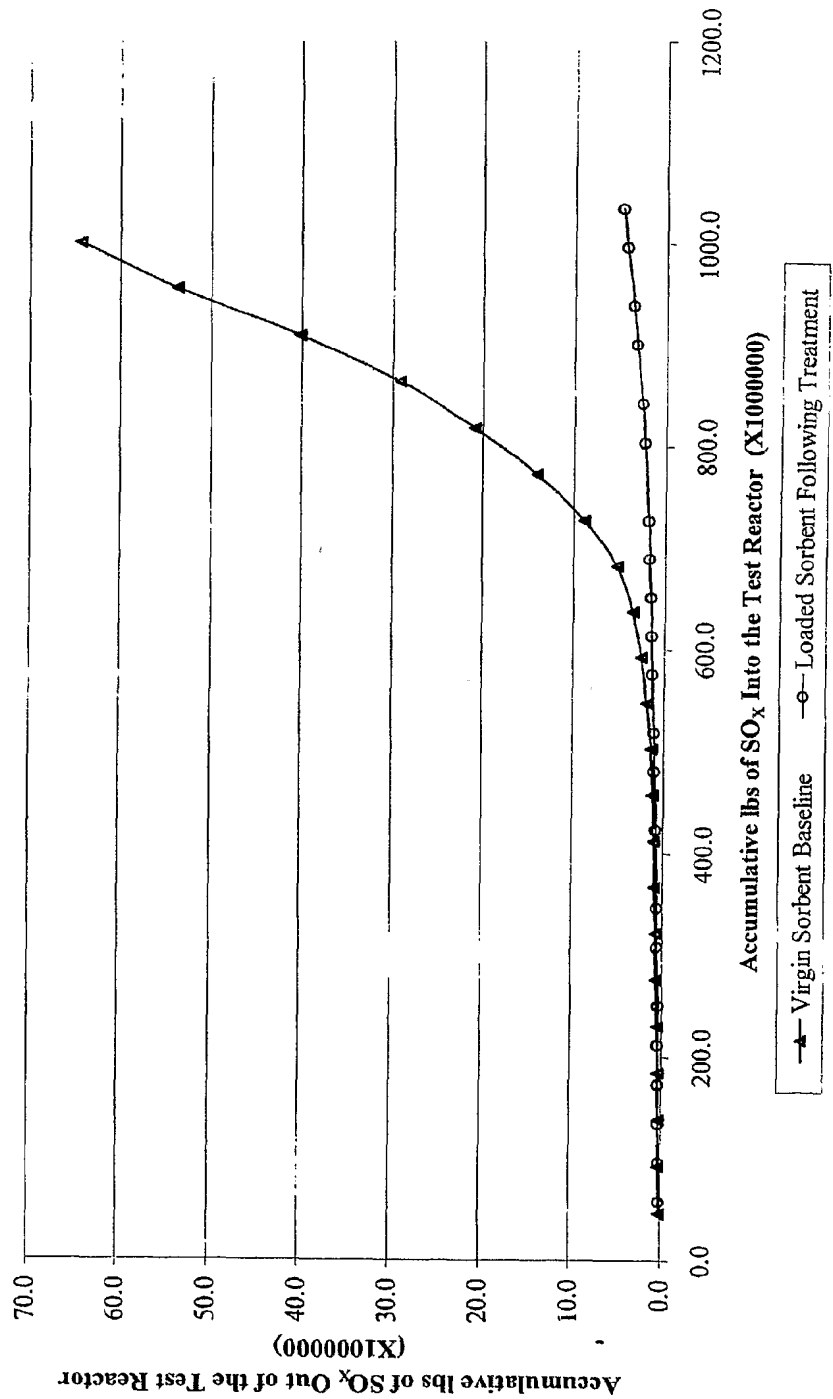
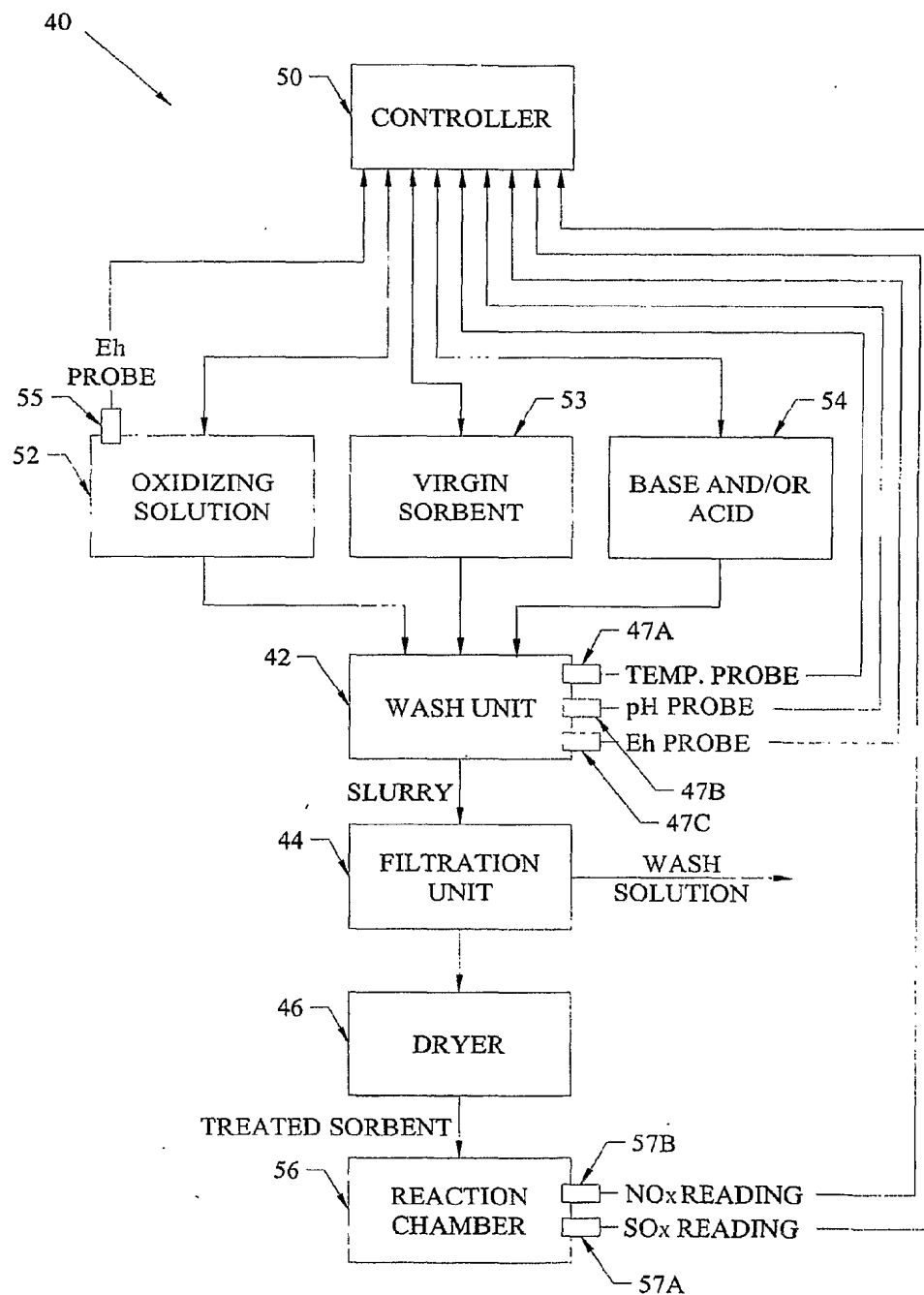


Figure 6
SO_x Loading of Previously Loaded Sorbent Following Treatment
with an Oxidizing Aqueous Rinse as Defined in Applicants Invention.



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FIGURE 7
TREATMENT OF VIRGIN OXIDES OF MANGANESE SORBENT



8/10
FIGURE 8
TREATMENT OF LOADED OXIDES OF MANGANESE SORBENT

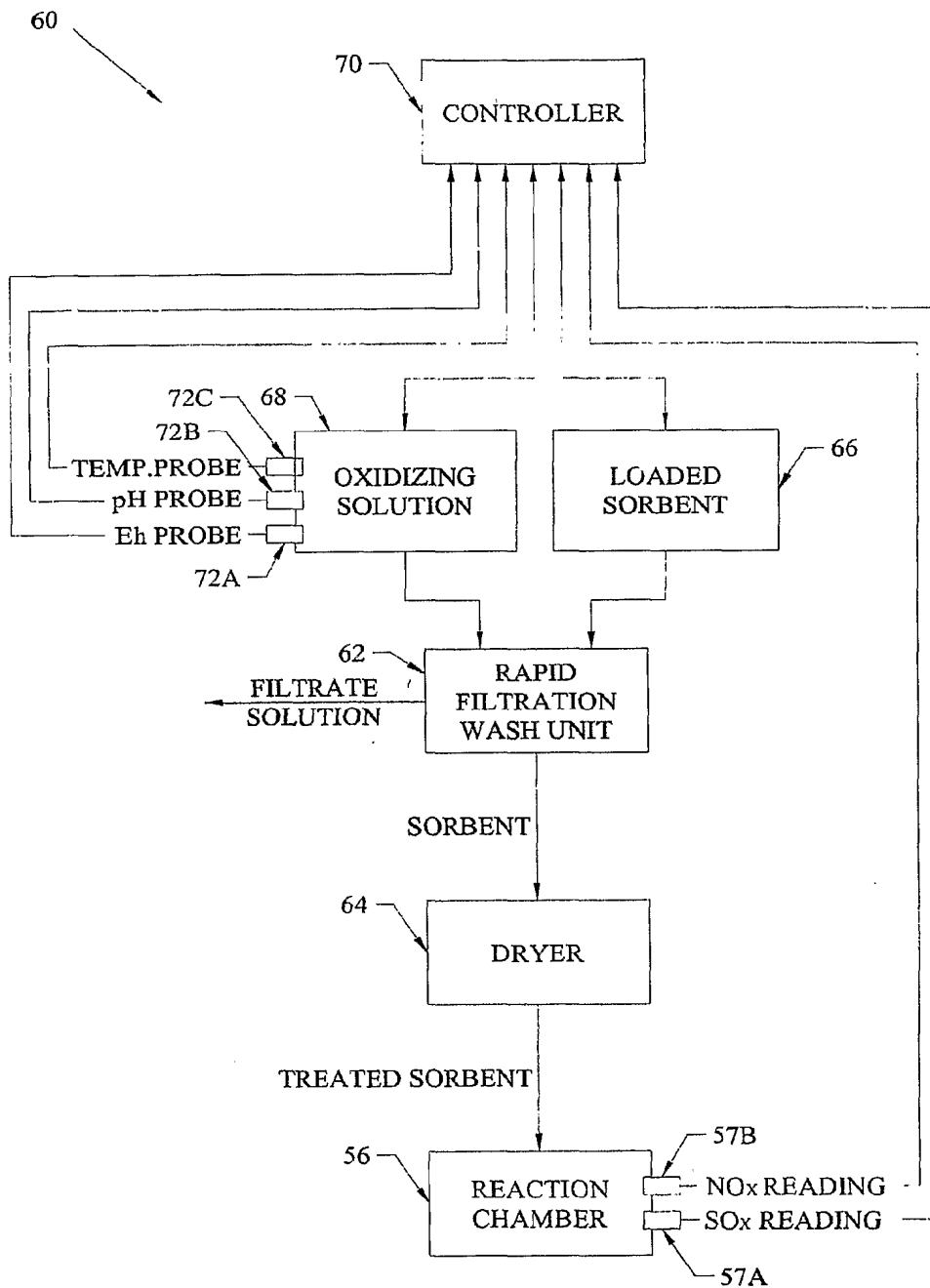


FIGURE 9
POURBAIX DIAGRAM AT 25° C WITH 1×10^{-6} DISSOLVED MANGANESE
CONCENTRATION

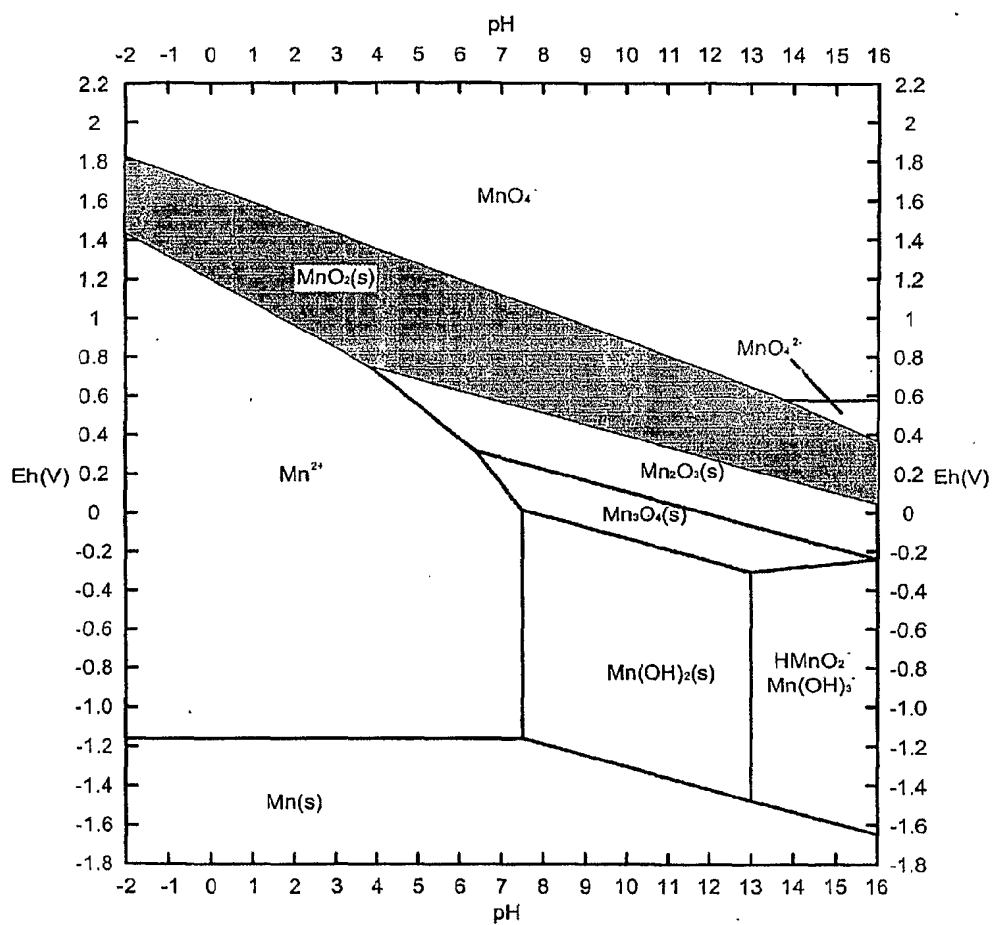
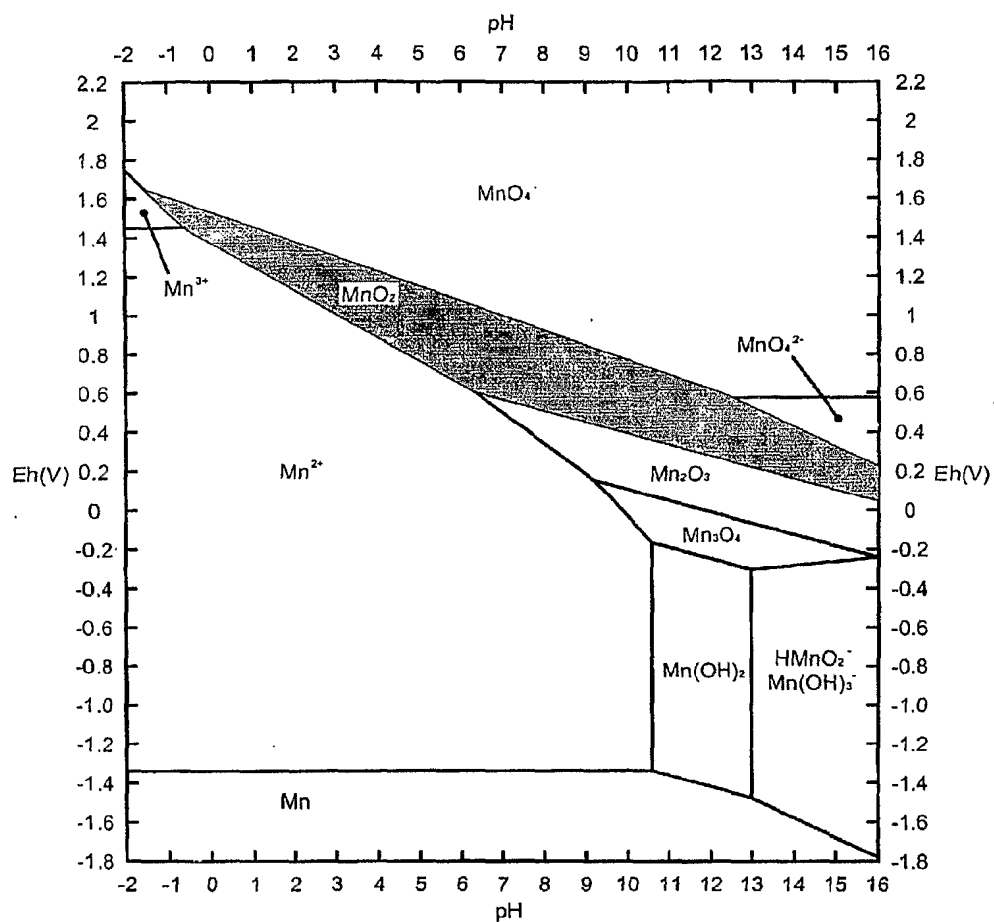


FIGURE 10
POURBAIX DIAGRAM AT 25° C WITH 1×10^{-6} DISSOLVED MANGANESE
CONCENTRATION



INTERNATIONAL SEARCH REPORT

International Application No

PCT/US 02/41276

A. CLASSIFICATION OF SUBJECT MATTER

IPC 7 B01J20/06 B01J20/34 B01J23/34

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

IPC 7 B01J

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

EPO-Internal, WPI Data, PAJ

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 4 552 734 A (IANNICELLI JOSEPH ET AL) 12 November 1985 (1985-11-12) column 4, line 7 -column 9, line 65; claims; figures; examples ---	1-34
X	US 5 366 710 A (CHOU CHARLES C ET AL) 22 November 1994 (1994-11-22) column 2, line 53 -column 5, line 68; claims; figures; examples; tables ---	1-34
X	US 4 164 545 A (SCOTT RICHARD L) 14 August 1979 (1979-08-14) column 1, line 8 -column 4, line 39; claims; figures; examples; tables --- -/--	1-34



Further documents are listed in the continuation of box C.



Patent family members are listed in annex.

* Special categories of cited documents:

A document defining the general state of the art which is not considered to be of particular relevance

E earlier document but published on or after the international filing date

L document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)

O document referring to an oral disclosure, use, exhibition or other means

P document published prior to the international filing date but later than the priority date claimed

T later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention

X document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone

Y document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art.

& document member of the same patent family

Date of the actual completion of the international search

13 June 2003

Date of mailing of the international search report

27/06/2003

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INTERNATIONAL SEARCH REPORT

International Application No

PCT/US 02/41276

C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 4 923 688 A (IANNICELLI JOSEPH) 8 May 1990 (1990-05-08) column 2, line 67 -column 8, line 45; claims; figures; examples ---	1-34
P,X	WO 02 28513 A (ENVIROSCRUB TECHNOLOGIES CORP) 11 April 2002 (2002-04-11) the whole document -----	1-34
P,X	WO 02 09852 A (ENVIROSCRUB TECHNOLOGIES CORP ;PAHLMAN KATHLEEN S HF (US); AXEN ST) 7 February 2002 (2002-02-07) the whole document -----	1-34

INTERNATIONAL SEARCH REPORT

International application No.
PCT/US 02/41276

Box I Observations where certain claims were found unsearchable (Continuation of item 1 of first sheet)

This International Search Report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1. ☐ Claims Nos.:
because they relate to subject matter not required to be searched by this Authority, namely:
2. ☒ Claims Nos.:
because they relate to parts of the International Application that do not comply with the prescribed requirements to such an extent that no meaningful International Search can be carried out, specifically:
see FURTHER INFORMATION sheet PCT/ISA/210
3. ☐ Claims Nos.:
because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

Box II Observations where unity of invention is lacking (Continuation of item 2 of first sheet)

This International Searching Authority found multiple inventions in this international application, as follows:

1. ☐ As all required additional search fees were timely paid by the applicant, this International Search Report covers all searchable claims.
2. ☐ As all searchable claims could be searched without effort justifying an additional fee, this Authority did not invite payment of any additional fee.
3. ☐ As only some of the required additional search fees were timely paid by the applicant, this International Search Report covers only those claims for which fees were paid, specifically claims Nos.:
4. ☐ No required additional search fees were timely paid by the applicant. Consequently, this International Search Report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

Remark on Protest

- ☐ The additional search fees were accompanied by the applicant's protest.
- ☐ No protest accompanied the payment of additional search fees.

FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210

Continuation of Box I.2

In view of the large number and also the wording of the claims presently on file, which render it difficult, if not impossible, to determine the matter for which protection is sought, the present application fails to comply with the clarity and conciseness requirements of Article 6 PCT (see also Rule 6.1(a) PCT) to such an extent that a meaningful search is impossible. Consequently, the search has been carried out for those parts of the application which do appear to be clear (and concise), namely a process for the (pre)treatment of oxides of manganese, a system therefore and the products thereof as described in the lab-scale test on page 25 to 29.

The applicant's attention is drawn to the fact that claims, or parts of claims, relating to inventions in respect of which no international search report has been established need not be the subject of an international preliminary examination (Rule 66.1(e) PCT). The applicant is advised that the EPO policy when acting as an International Preliminary Examining Authority is normally not to carry out a preliminary examination on matter which has not been searched. This is the case irrespective of whether or not the claims are amended following receipt of the search report or during any Chapter II procedure.

INTERNATIONAL SEARCH REPORT

Information on patent family members

International Application No

PCT/US 02/41276

Patent document cited in search report		Publication date	Patent family member(s)	Publication date
US 4552734	A	12-11-1985	CA 1216732 A1 DK 410584 A GB 2149389 A ,B	20-01-1987 09-03-1985 12-06-1985
US 5366710	A	22-11-1994	NONE	
US 4164545	A	14-08-1979	NONE	
US 4923688	A	08-05-1990	NONE	
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